



Oxide nanosheets as seed layers for growth of complex oxides on Si and glass



ISCR, Rennes: F. Baudouin, S. Gaddour, M. Barrabe, S. Ollivier, M. Chettab, S. Députier, M. Guilloux-Viry, V. Demange



CRISMAT, Caen: A. Boileau, M. Dallochio, A. David, U. Lüders, W. Prellier, A. Fouchet



GEMaC, Versailles: B. Bérini, Y. Dumont



P', Poitiers: S. Hurand



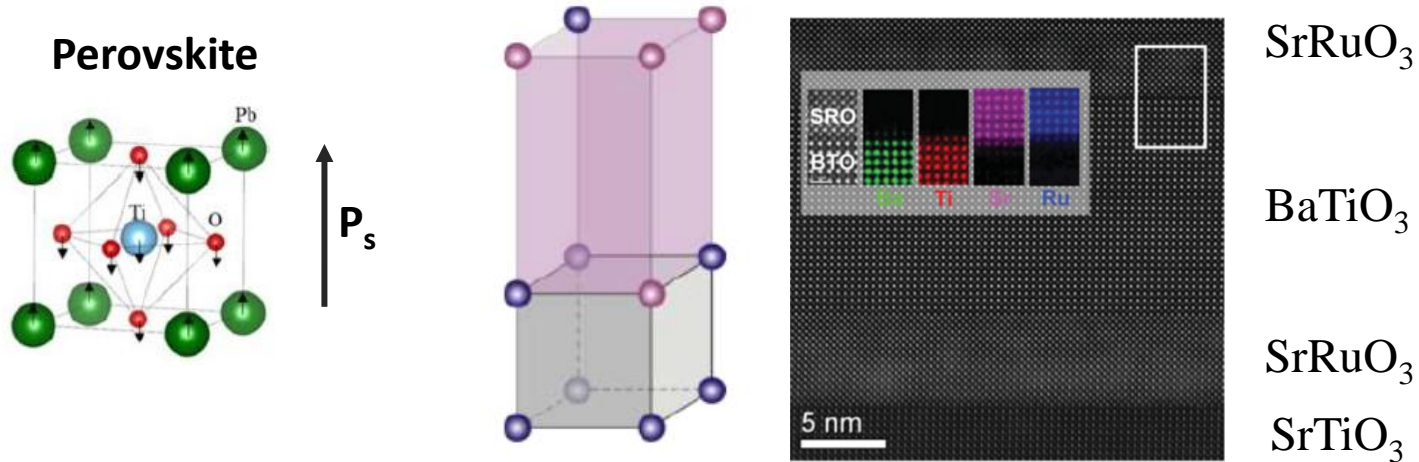
Oxide thin films

Functional oxides: ferroelectricity, ferromagnetism, multiferroism, electric conductivity, ionic conductivity, electro-optics, catalysis ...

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Epitaxial growth on single crystalline oxide substrates: SrTiO_3 , LaAlO_3 , MgO , ...

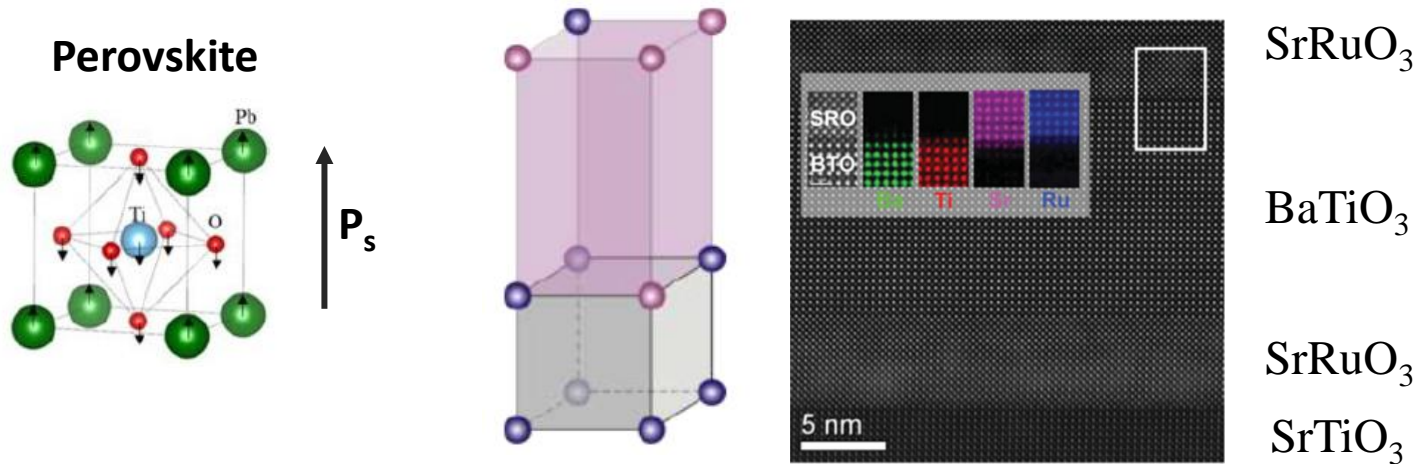


M. F. Sarott, E. Gradauskaite, J. Nordlander,
N. Strkalj, M. Trassin. *J. Phys.: Condens. Matter.* **33** (2021) 293001

Oxide thin films

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Complex oxides substrates:

- Expensive
- Difficult to process
- Limited size
- Limited use in industry

Difficulty to integrate oxides on silicon and glass:

- High reactivity of Si with O₂: propensity to form amorphous SiO₂ at the interface
- Structural and chemical dissimilarities
- Differences in thermal expansion coefficients
- Reaction of oxides with Si



- Very low crystalline quality
- Degradation of the properties

Difficulty to integrate oxides on silicon and glass:

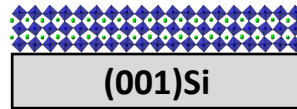
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Breakthrough 1998: McKee *et al.* PRL 81 : first demonstration that SrTiO₃ can be grown directly on Si with an atomically sharp interface using MBE

Heteroepitaxy of a thin template layer
of SrTiO₃ on Si



SrTiO₃
Y₂O₃:ZrO₂ (YSZ)
CeO₂/YSZ

template layer by **Pulsed Layer Deposition (PLD)**

Fork *et al.* APL 57 (1990) 1137
Perna *et al.* J. Phys. Cond. Matter. 21 (2009) 30
Diaz-Fernandez *et al.* Appl. Surf. Sci. 455 (2018) 227

ZrO₂ template layer by **Atomic Layer Deposition (ALD)**

Dogan *et al.* J. Phys. Chem. C 123 (2019) 15053

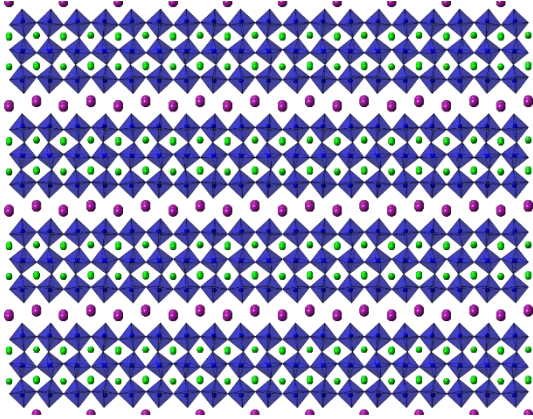
Limitations: Complex technics

Advantages: High crystalline quality of the template layer

Oxide metals nanosheets: template layers for oxides

Pioneer work of Sasaki's group (NIMS, Japan), 2007

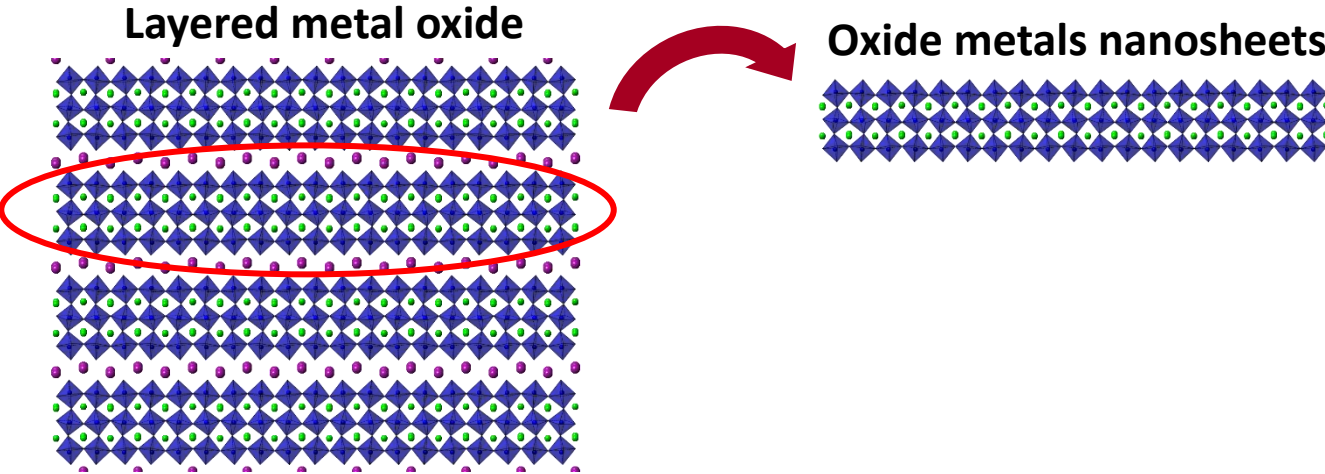
Layered metal oxide



Oxide metals nanosheets: template layers for oxides

Pioneer work of Sasaki's group (NIMS, Japan), 2007

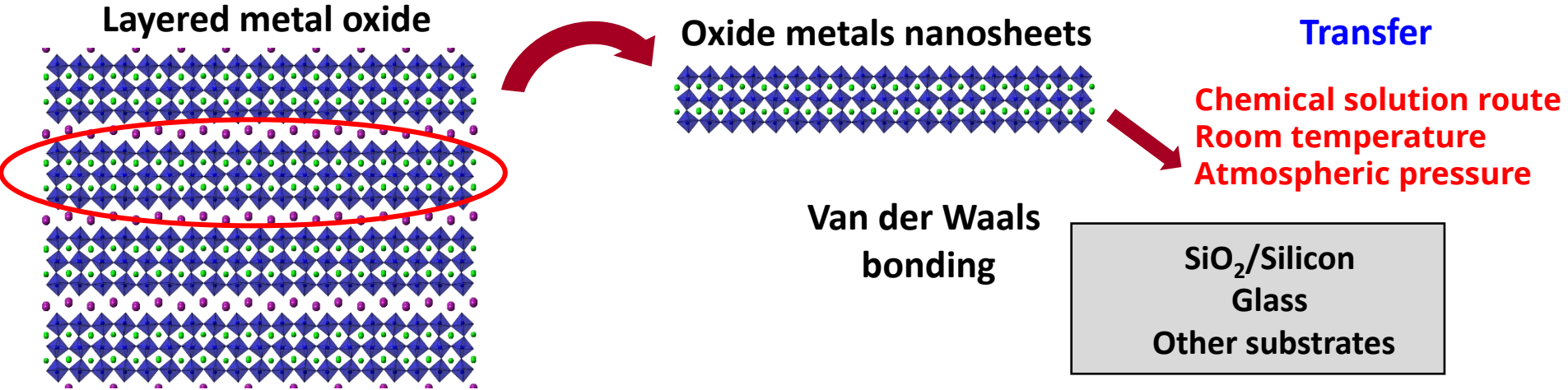
Exfoliation in solution



Oxide metals nanosheets: template layers for oxides

Pioneer work of Sasaki's group (NIMS, Japan), 2007

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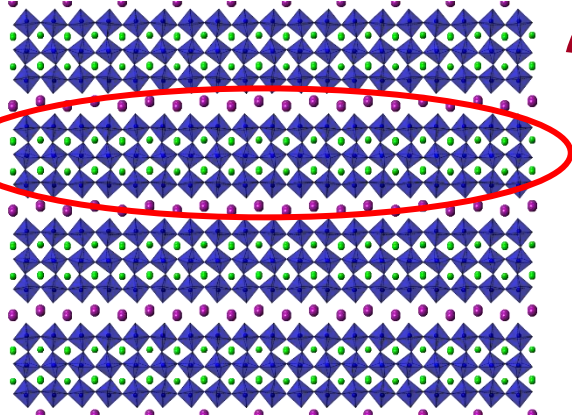


Oxide metals nanosheets: template layers for oxides

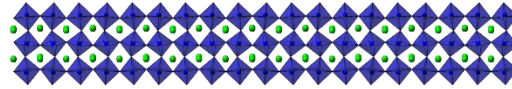
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Exfoliation in solution

Layered metal oxide



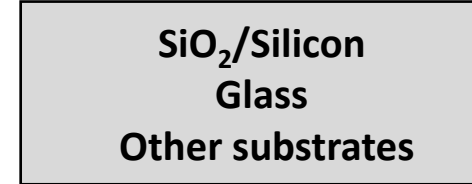
Oxide metals nanosheets



Transfer

Chemical solution route
Room temperature
Atmospheric pressure

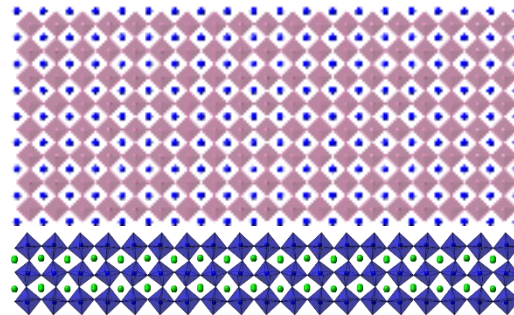
Van der Waals
bonding



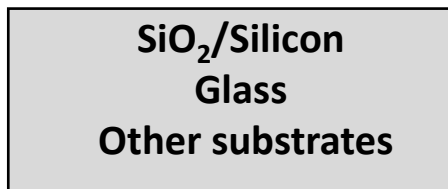
Growth

PLD, PVD, CSD, ALD

(Oxide) thin film



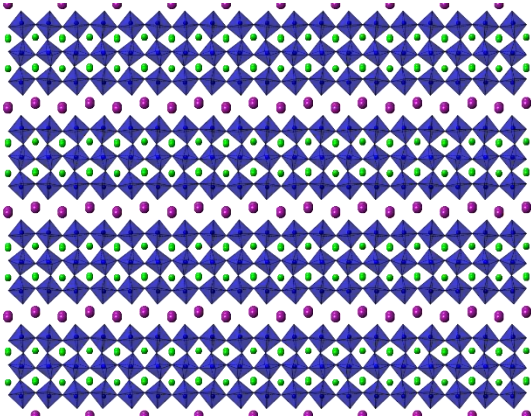
Oxide nanosheet



Oxide metals nanosheets: template layers for oxides

Synthesis

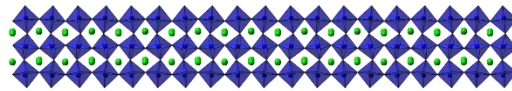
Layered metal oxide



Synthesis: 2 weeks
Storage: years

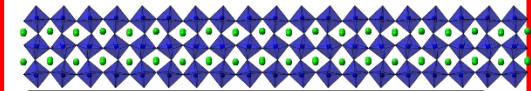
Exfoliation in solution

Oxide metals nanosheets



Synthesis: 2 weeks
Storage: 6 months

Transfer



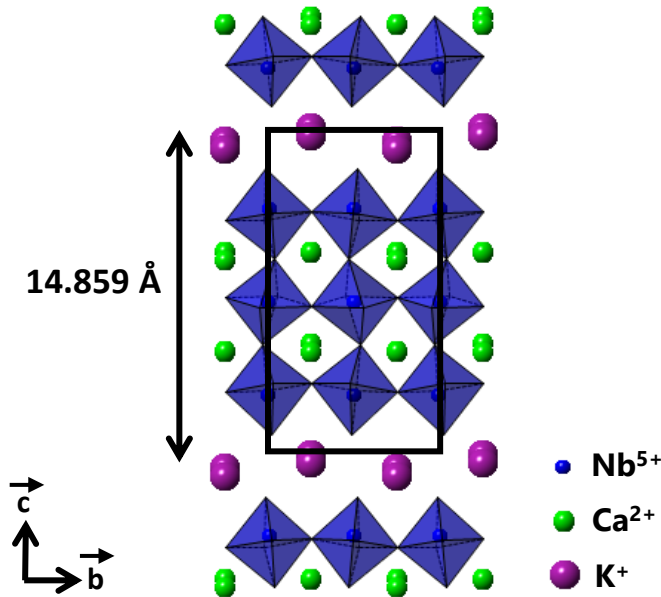
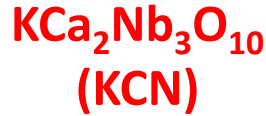
SiO₂/Silicon
Glass
Other substrates

Process: 3 hours
Storage: > 1 year

[Ca₂Nb₃O₁₀]⁻: nanosheets for the growth of (001) perovskite

Layered perovskite Dion-Jacobson phase: AA'_{k-1}B_kO_{3k+1}

A: alkaline metal, A': alkaline-earth metal, B: transition metal



P*2₁/*m

***a* = 7.741 Å, *b* = 7.707 Å, *c* = 14.859 Å, β = 97.51°**

(larger tetragonal cell description: a = 7.727 Å, b = 29.466 Å)

M. Dion, M. Ganne, M. Tournoux. *Mater. Res. Bull.* **16** (1981) 1429

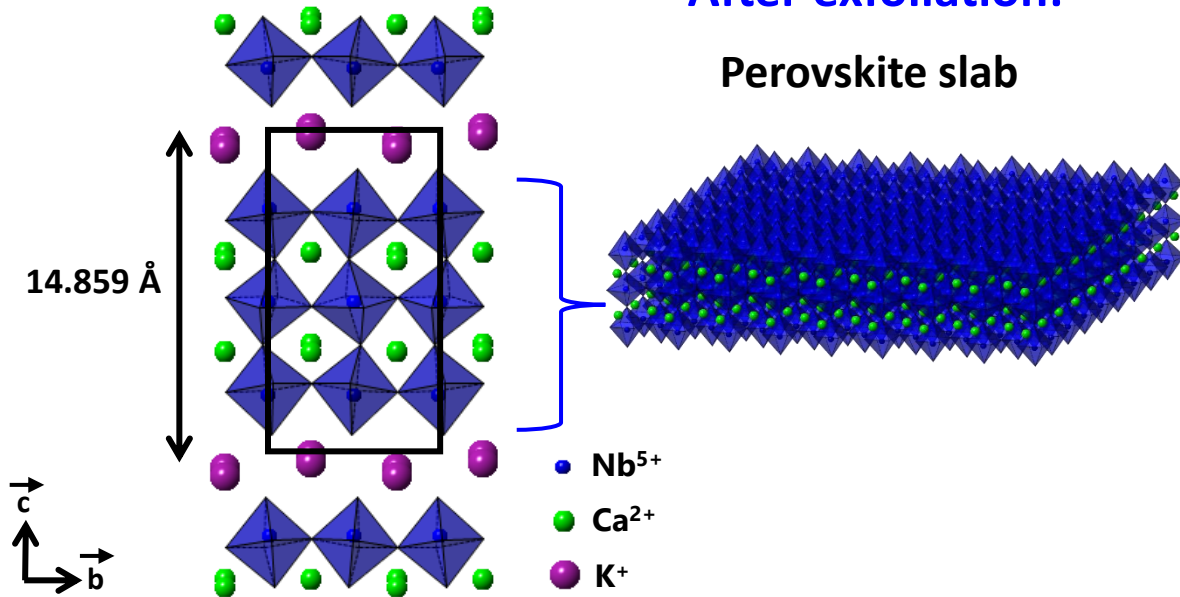
T. Tokumitsu, K. Toda, T. Aoyagi, D. Sakuraba, K. Uematsu, M. Sato. *J. Ceram. Soc. Jpn.* **114** (2006) 795

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Layered perovskite Dion-Jacobson phase: AA'_{k-1}B_kO_{3k+1}

A: alkaline metal, A': alkaline-earth metal, B: transition metal

KCa₂Nb₃O₁₀
(KCN)



$P2_1/m$

$a = 7.741 \text{ \AA}, b = 7.707 \text{ \AA}, c = 14.859 \text{ \AA}, \beta = 97.51^\circ$

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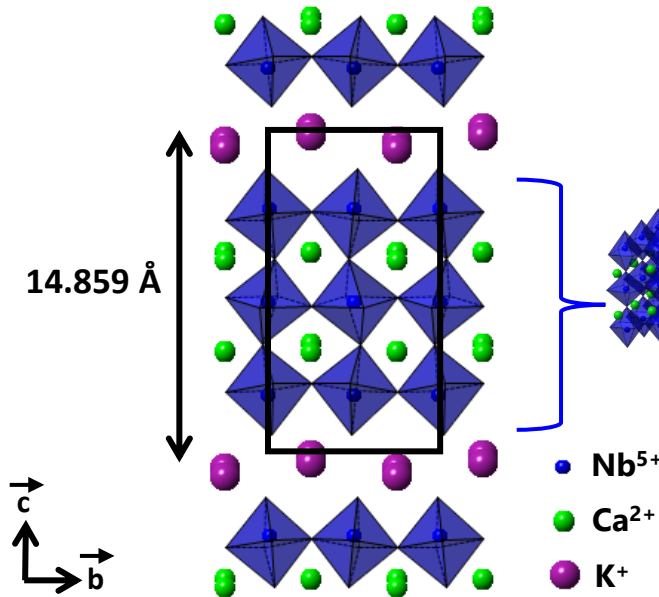
T. Tokumitsu, K. Toda, T. Aoyagi, D. Sakuraba, K. Uematsu, M. Sato. *J. Ceram. Soc. Jpn.* **114** (2006) 795

$[\text{Ca}_2\text{Nb}_3\text{O}_{10}]^-$: nanosheets for the growth of (001) perovskite

Layered perovskite Dion-Jacobson phase: $\text{AA}'_{k-1}\text{B}_k\text{O}_{3k+1}$

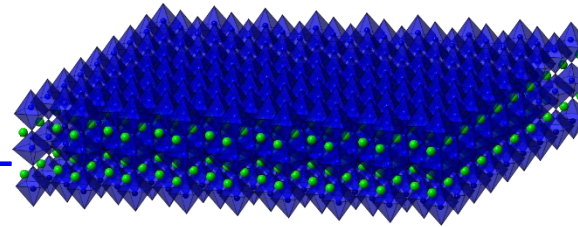
A: alkaline metal, A': alkaline-earth metal, B: transition metal

$\text{KCa}_2\text{Nb}_3\text{O}_{10}$
(KCN)

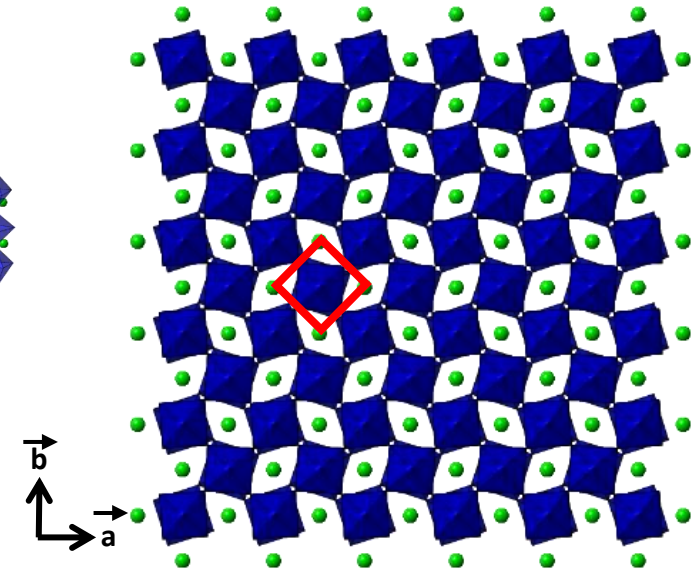


After exfoliation:

Perovskite slab



In plane view of $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]^-$



$P2_1/m$

$a = 7.741 \text{ \AA}$, $b = 7.707 \text{ \AA}$, $c = 14.859 \text{ \AA}$, $\beta = 97.51^\circ$

(larger tetragonal cell description: $a = 7.727 \text{ \AA}$, $b = 29.466 \text{ \AA}$)

Square lattice:

$a_{NS} \sim 3.85 \text{ \AA}$

M. Dion, M. Ganne, M. Tournoux. *Mater. Res. Bull.* **16** (1981) 1429

T. Tokumitsu, K. Toda, T. Aoyagi, D. Sakuraba, K. Uematsu, M. Sato. *J. Ceram. Soc. Jpn.* **114** (2006) 795

Nanosheets for preferential orientation of oxides on any substrate

PLD, Sputtering, Sol-gel

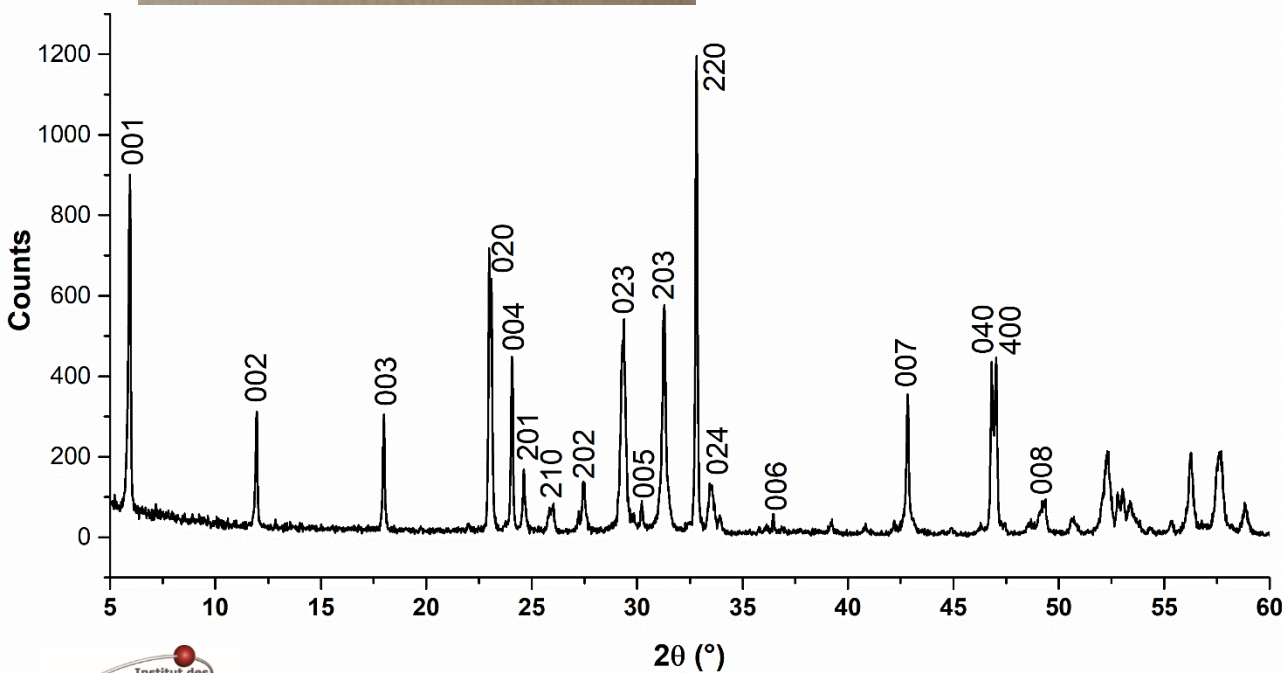
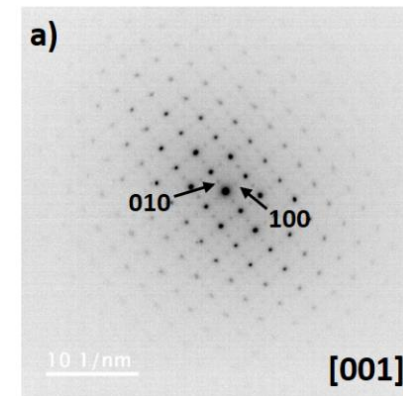
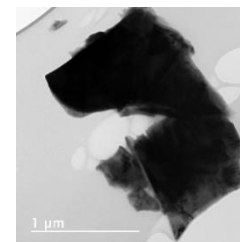
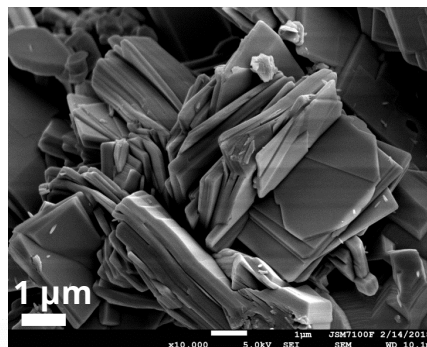
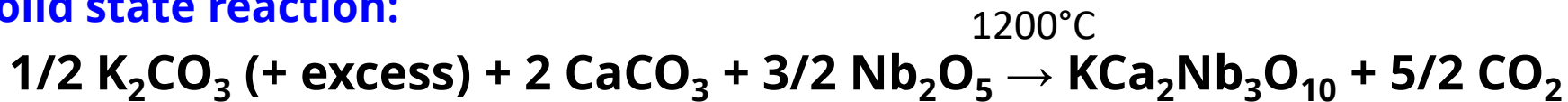
Nanosheets (NS)	2D lattice	Grown films on NS	Substrates
[Ca ₂ Nb ₃ O ₁₀] ⁻	<p>Square</p> <p>$a_{NS} = 3.85 \text{ \AA} \times 3.85 \text{ \AA}$</p> 	(001)SrTiO ₃ (001)(Ba,Sr)TiO ₃	Glass
		(001)LaMnO ₃ /STO SLs	Si
		(001)LAO/STO SLs	Si
		(001)LaNiO ₃	Si
		(001)BaTiO ₃	Si
		(001)(K,Na)NbO ₃	Pt/Ti/SiO ₂ /Si
		(001)BiFeO ₃	Pt/Si, Pt/TiO ₂ /Si, 316LSS
		(001)Pb(Zr,Ti)O ₃	Si, Pt/TiO ₂ /Si, glass, 316LSS
		(001)SrRuO ₃	Si, Glass
		(001)(Ca,Sr)Bi ₄ Ti ₄ O ₁₅	Pt/TiO ₂ /Si
		(110)(Sr,Eu) ₂ (Sn,Ti)O ₄	Glass
		(001)TiO ₂	Glass

Refs: Sasaki's articles, Ten Elshof's articles, ...

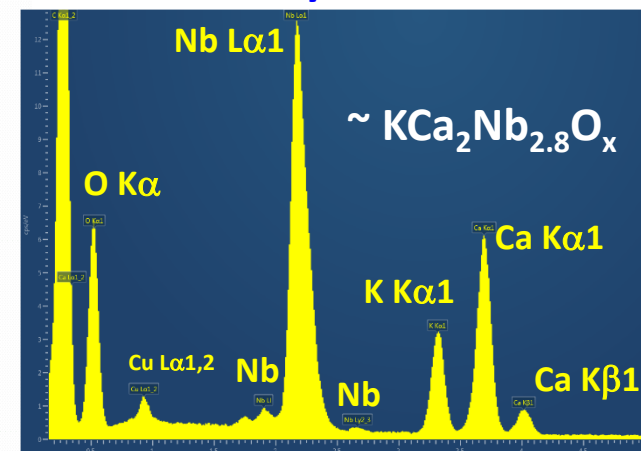
Synthesis of $\text{KCa}_2\text{Nb}_3\text{O}_{10}$

F. Baudouin

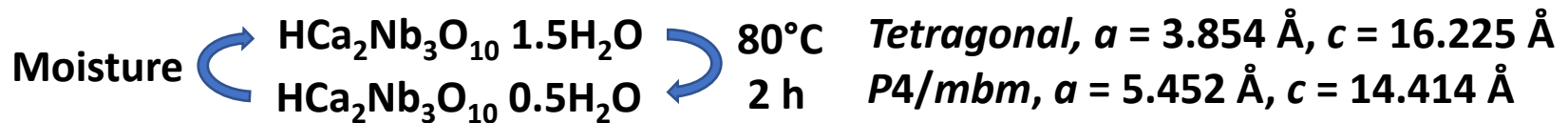
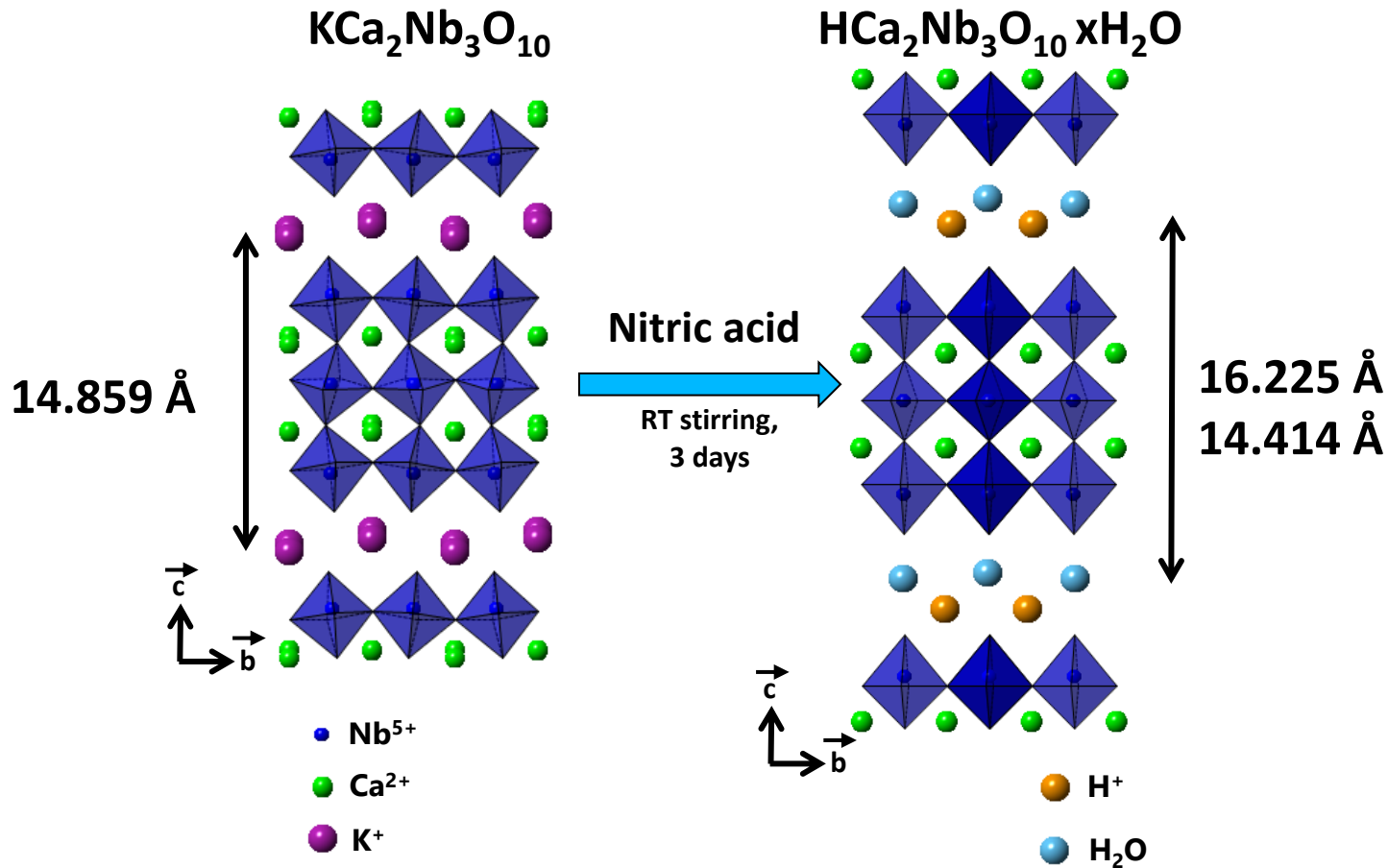
Solid state reaction:



EDXS analysis



Protonation: ion exchange $K^+ \rightarrow H^+$

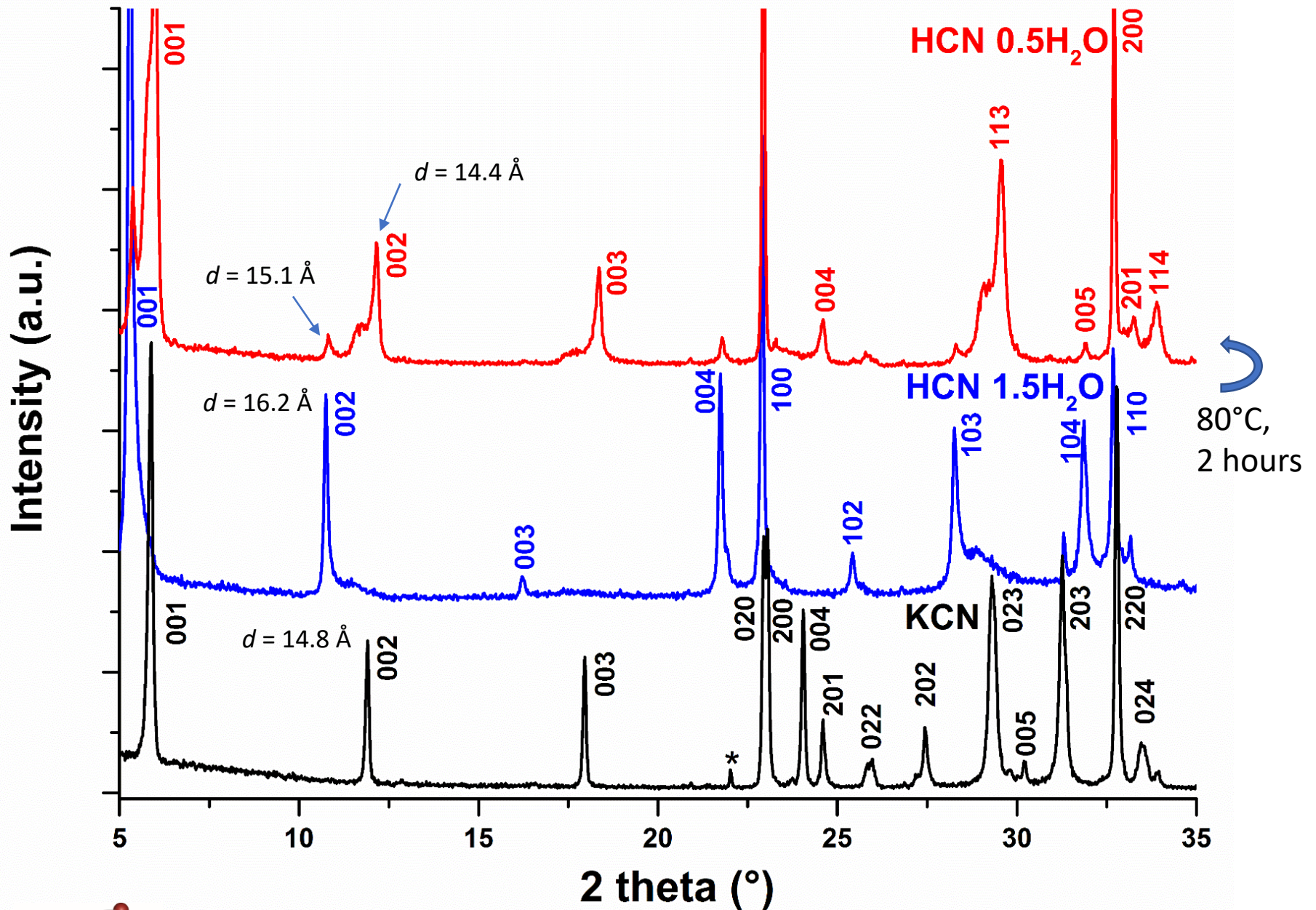


A.J. Jacobson, J.T. Lewandowski, J.W. Johnson. *J. Common Met.* **116** (1986) 137

Y. Chen, X. Zhao, H. Ma, S. Ma, G. Huang, Y. Makita, X. Bai, X. Yang. *J. Solid State Chem.* **181** (2008) 1684

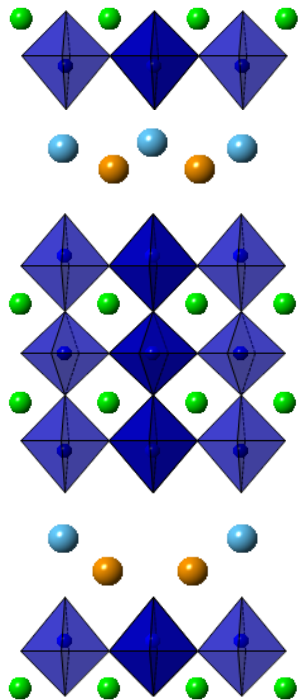
L.V. Yafarova, O.I. Silyukov, T.D. Myshkovskaya, I.A. Minich, I.A. Zvereva. *J. Therm. Analysis. Calorim.* (2020)

X-ray diffraction

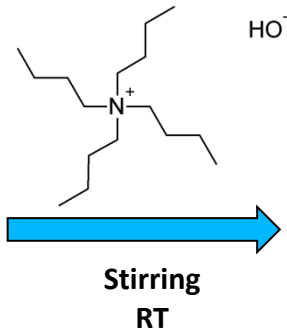


Exfoliation

HCN 1.5H₂O



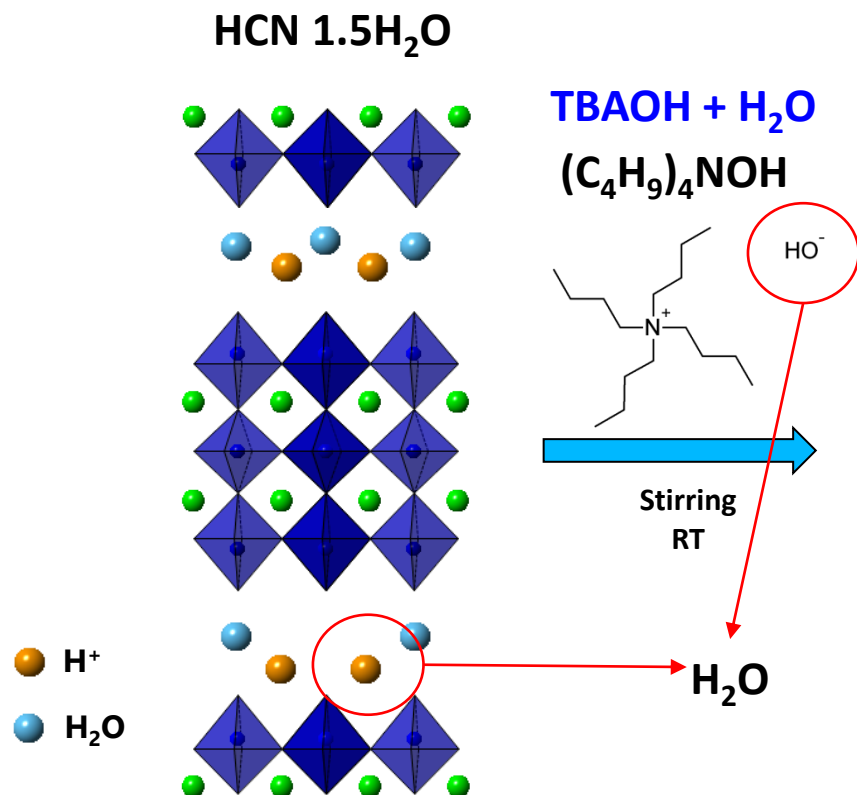
TBAOH + H₂O
(C₄H₉)₄NOH



Tetra(n-butyl)ammonium hydroxide (TBAOH)

R.E. Schaak, T. Mallouk. *Chem. Mater.* **12** (2000) 2513
H. Yuan, D. Dubbink, R. Besselink, J.E. Elshof. *Angew. Chemie. Int. Ed.* **54** (2015) 9239
J.E. Elshof, H. Yuan, P Gonzalez Rodriguez. *Mater. Views.* **6** (2016) 1600355

Exfoliation



Tetra(n-butyl)ammonium hydroxide (TBAOH)

- Acid-base reaction between OH⁻ from TBAOH and H⁺ from HCN

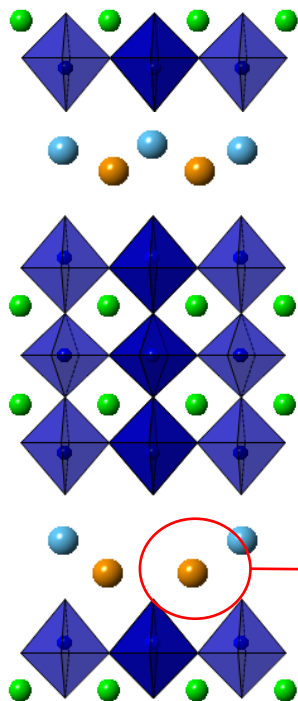
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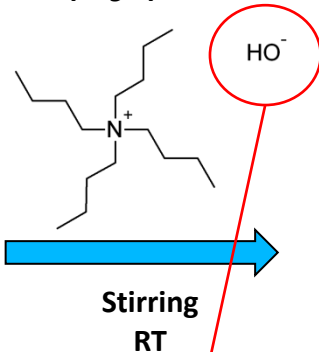
J.E. Elshof, H. Yuan, P Gonzalez Rodriguez. *Mater. Views.* **6** (2016) 1600355

Exfoliation

HCN 1.5H₂O



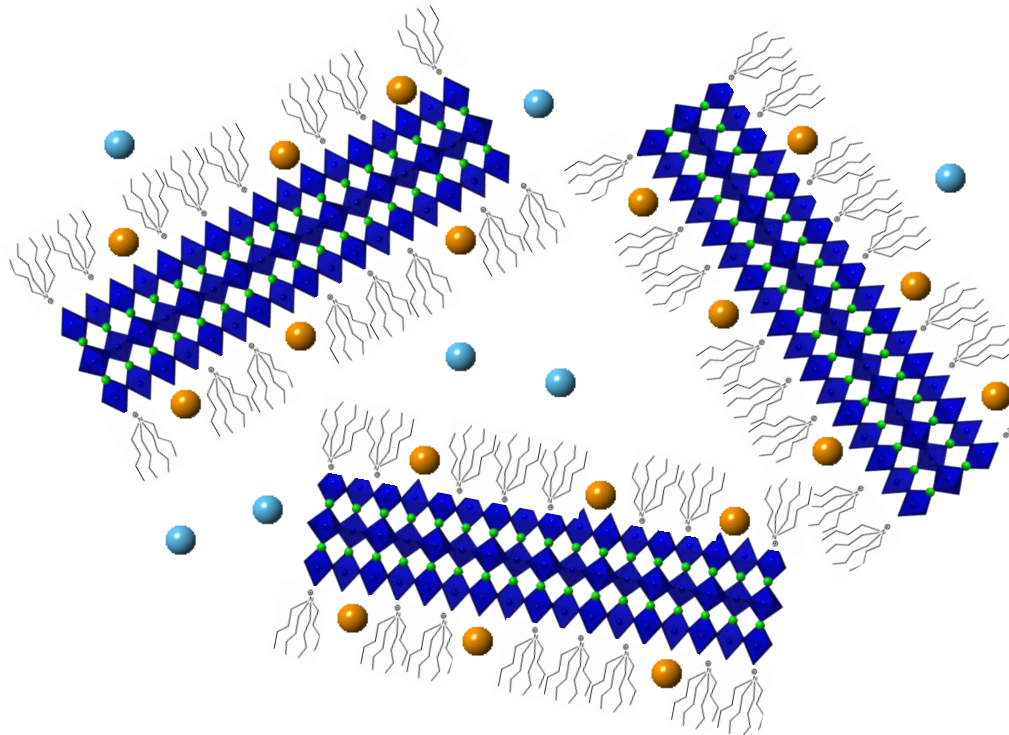
TBAOH + H₂O
(C₄H₉)₄NOH



● H⁺
● H₂O

H₂O

[H_{1-y}TBA_y]⁺[Ca₂Nb₃O₁₀]⁻ nanosheets
colloidal suspension



Nanosheets in solution:
[H_{1-y}TBA_y]⁺[Ca₂Nb₃O₁₀]⁻ + H₂O

Tetra(n-butyl)ammonium hydroxide (TBAOH)

- Acid-base reaction between OH⁻ from TBAOH and H⁺ from HCN
- TBA keep nanosheets in a well-dispersed state in water

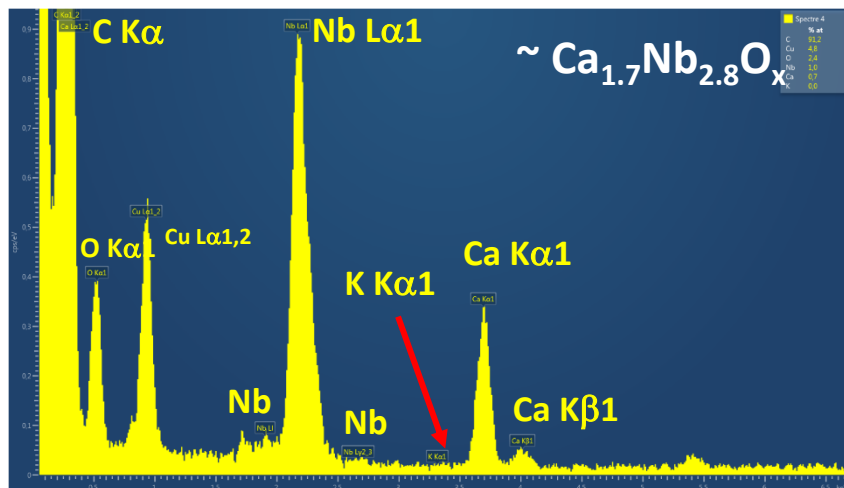
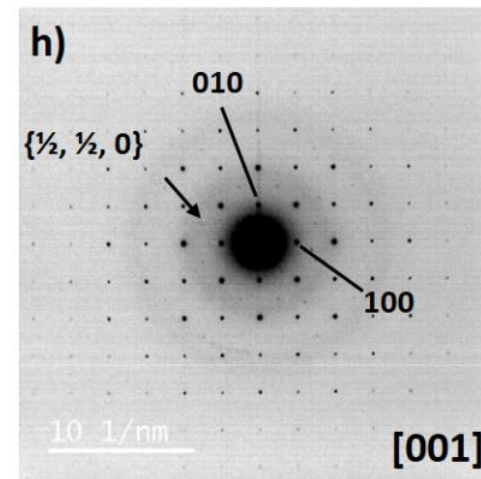
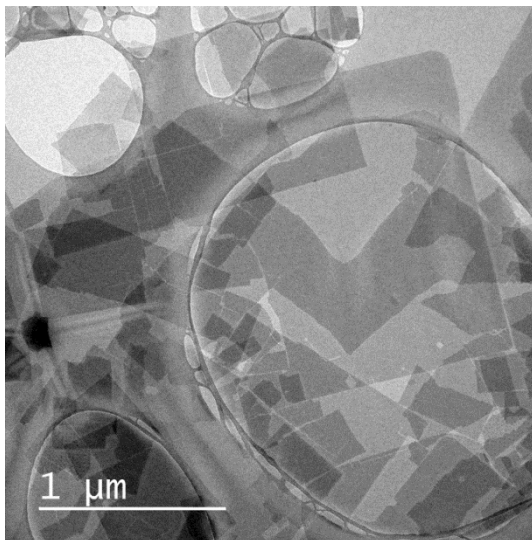


R.E. Schaak, T. Mallouk. *Chem. Mater.* **12** (2000) 2513
H. Yuan, D. Dubbink, R. Besselink, J.E. Elshof. *Angew. Chemie. Int. Ed.* **54** (2015) 9239
J.E. Elshof, H. Yuan, P Gonzalez Rodriguez. *Mater. Views.* **6** (2016) 1600355

[Ca₂Nb₃O₁₀]⁻ nanosheets



Nanosheet colloidal suspension:
Tyndall effect

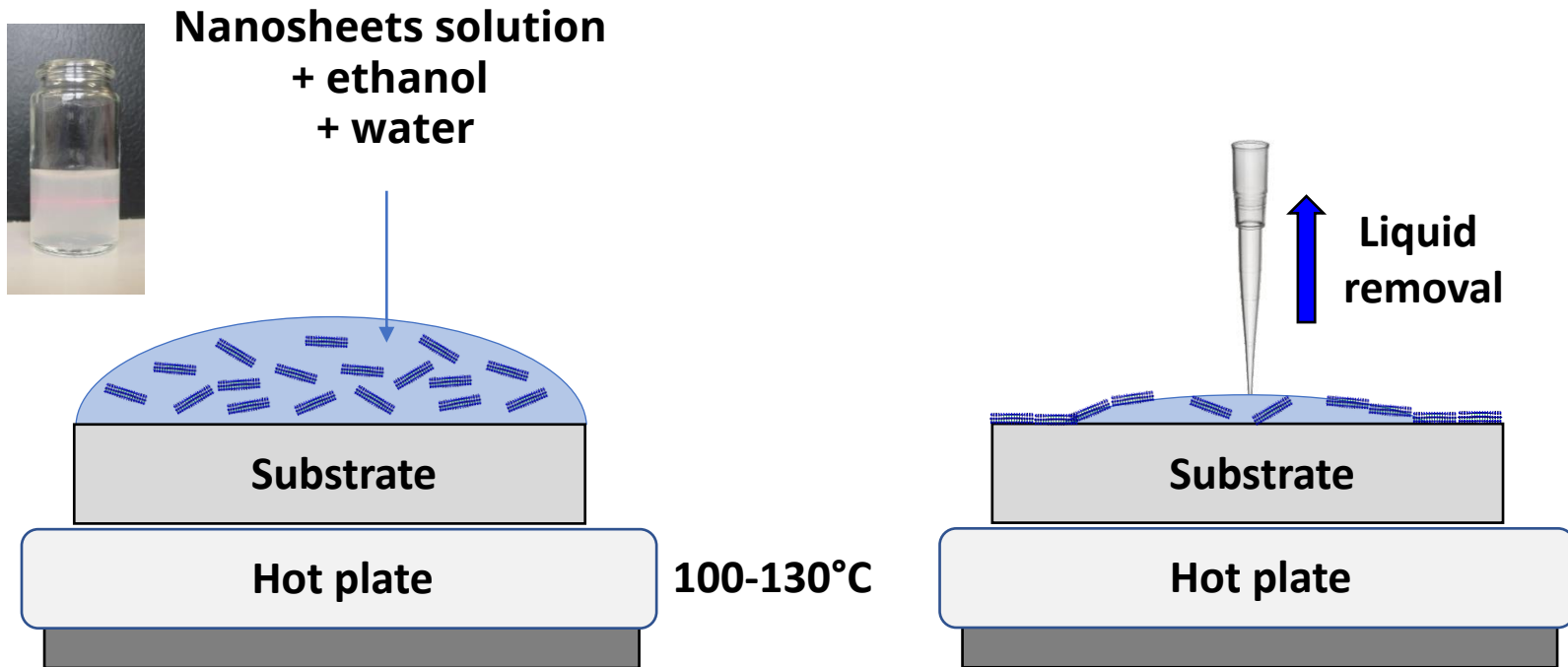


Weak superlattice $\{1/2, 1/2, 0\}$ reflections:
 $\sqrt{2}a$ lattice constant $\sim 5.46 \text{ \AA}$

A. Maia, F. Cheviré, V. Demange, V. Bouquet, M. Pasturel, S. Députier, R. Lebullenger, M. Guilloux-Viry, F. Tessier. *Solid State Sci.* **54** (2016) 17-21
 F. Baudouin, V. Demange, S. Ollivier, L. Rault, A. S. Brito, A. S. Maia, F. Gouttefangeas, V. Bouquet, S. Députier, B. Bérini, A. Fouchet, M. Guilloux-Viry. *Thin Solid Films* **693** (2020) 137682

Nanosheets seed layer deposition by drop-casting method

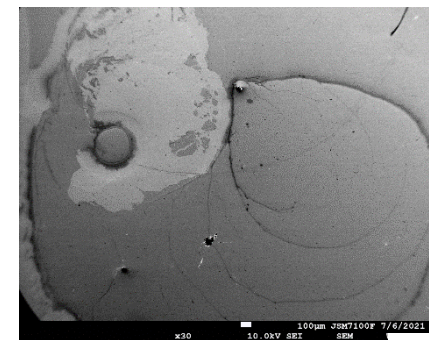
Y. Shi, M. Osada, Y. Ebina, T. Sasaki. *ACS Nano* **14** (2020) 15216



Easy
Fast (dozens samples/day)
No waste of material
Large substrates (several cm²)

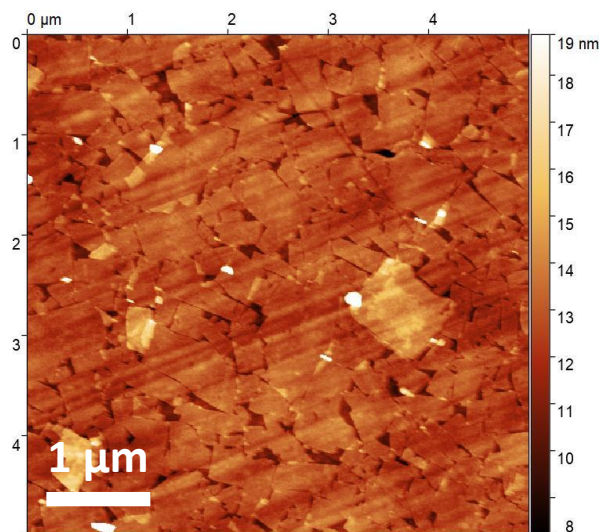
Limitations:

« Coffee-ring » marks
Operator dependent

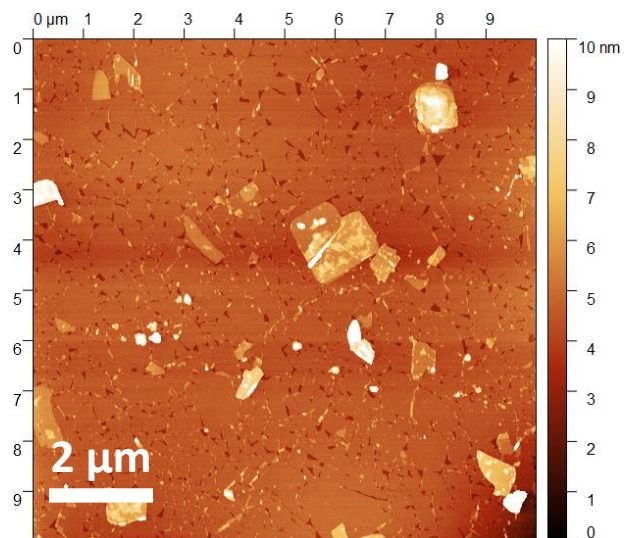


After deposition: atomic force microscopy/SEM

On SiO₂



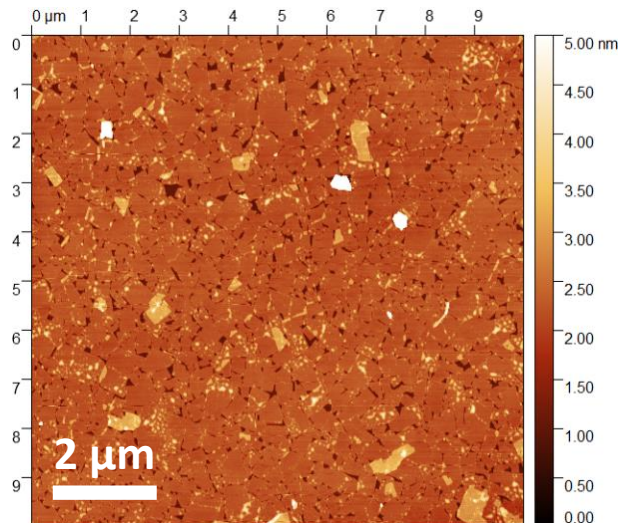
On (100)Si



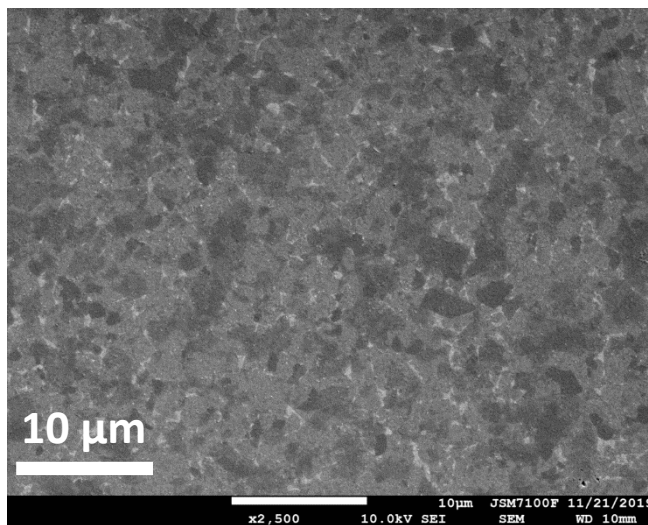
Height: $e = 1.5-1.9 \pm 0.3$ nm

Coverage: > 90 %

On mica

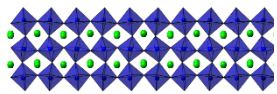
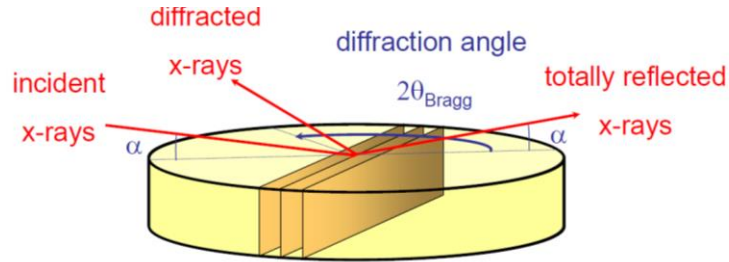
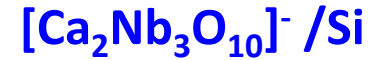


On Pt/Si

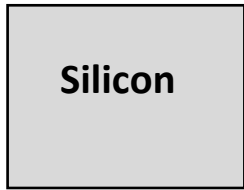


After deposition: in-plane X-ray diffraction

Rigaku 5-circles

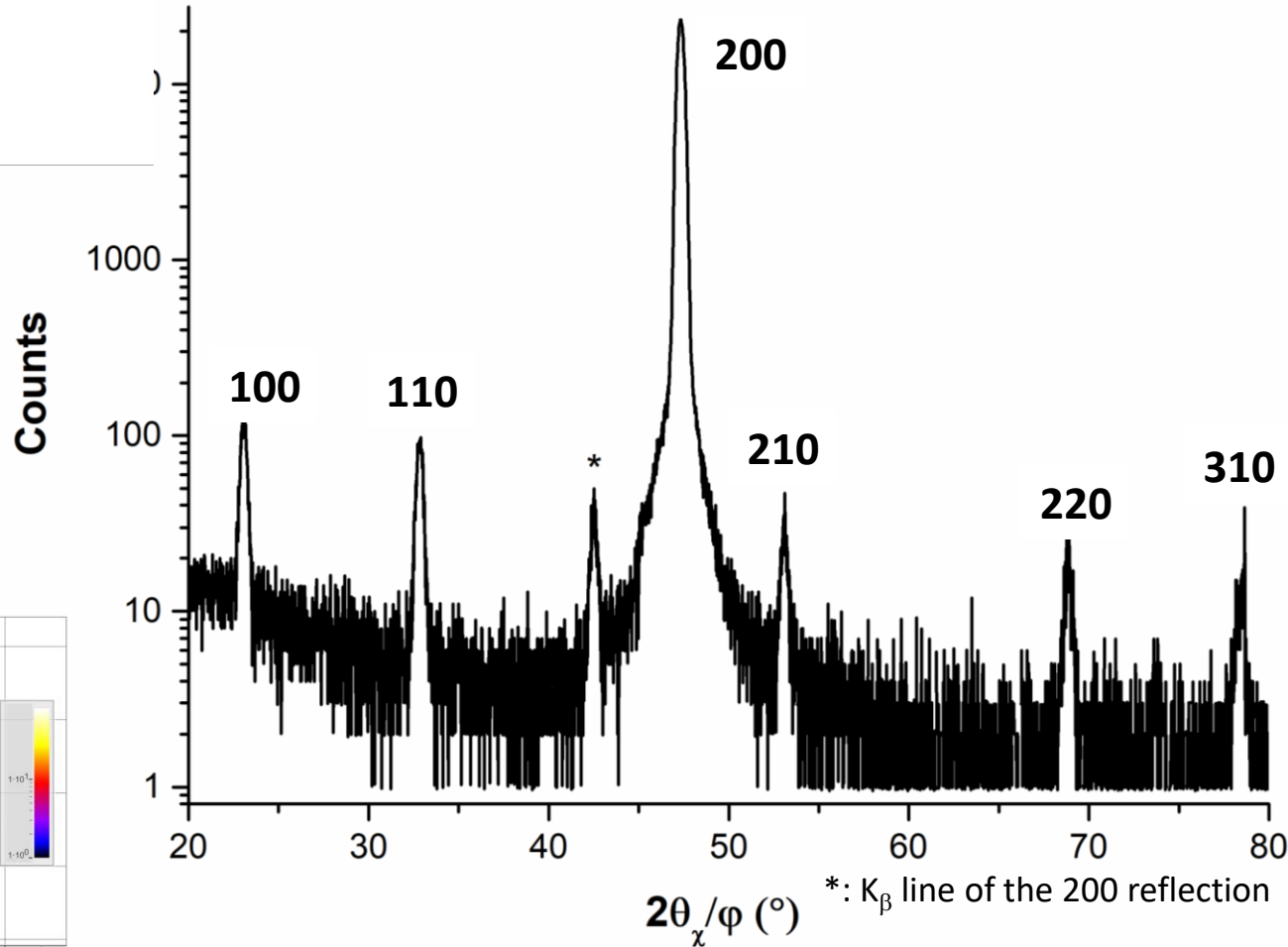
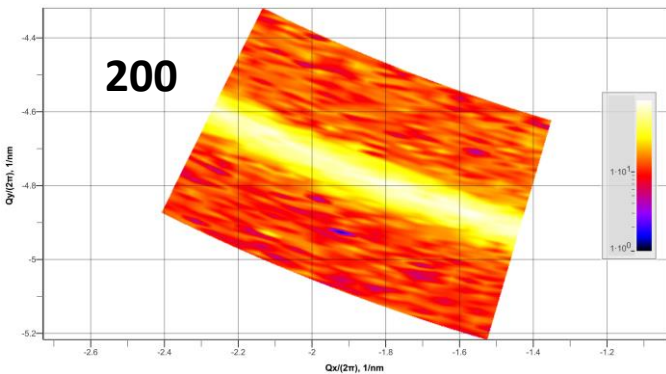


Thickness $\sim 1.5 \text{ nm}$



Silicon

In-plane RSM



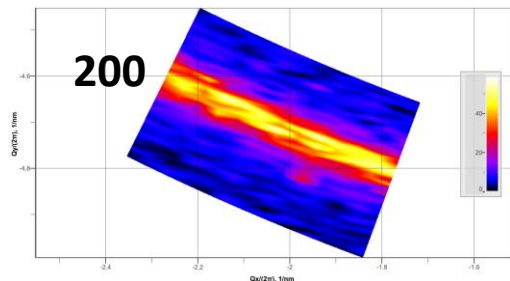
200 reflection $\Rightarrow a = 3.84 \text{ \AA}$

Random in-plane distribution of nanosheets on the substrate

➔ Texturation of the film grown on nanosheets covered substrate



$\text{La}_{0.67}\text{Sr}_{0.33}\text{MnO}_3$
on $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]^-/\text{glass}$



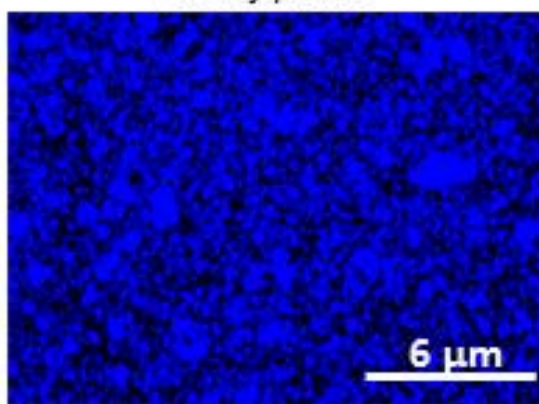
In-plane RSM

EBSD

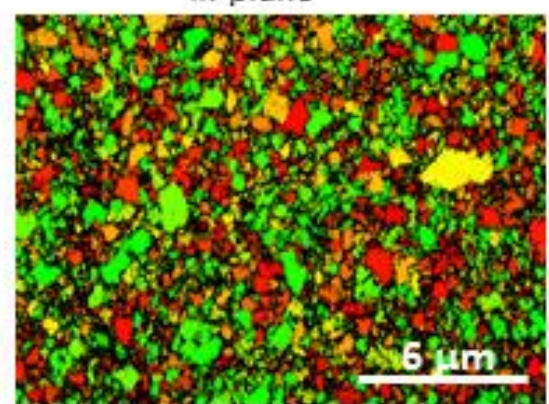
M. Dallochio

CaVO_3
on $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]^-/\text{glass}$

out-of-plane

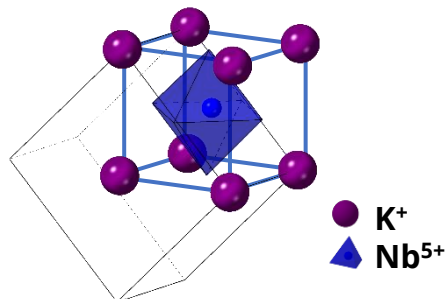
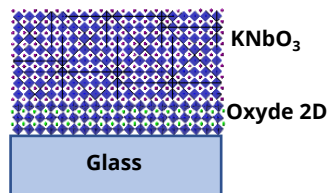


in-plane



Growth of complex oxides: KNbO_3 on $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]^-/\text{glass}$

Ferroelectric KNbO_3 (KNO)



Amm2

$a = 3.9741(0) \text{ \AA}$; $b = 5.6965(0) \text{ \AA}$; $c = 5.726(1) \text{ \AA}$

Pseudo-cubic cell:

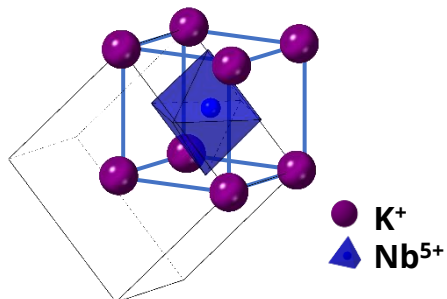
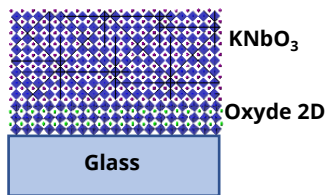
$a_{pc} = 3.971 \text{ \AA}$, $b_{pc} = 4.027 \text{ \AA}$, $c_{pc} = 4.045 \text{ \AA}$

L. Katz and H.D. Megaw. *Acta Cryst.* 22 (1967) 639

S. Kawamura *et al.* *Jpn J. Appl. Phys.* 52 (2013) 09KF04

Growth of complex oxides: KNbO_3 on $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]^-/\text{glass}$

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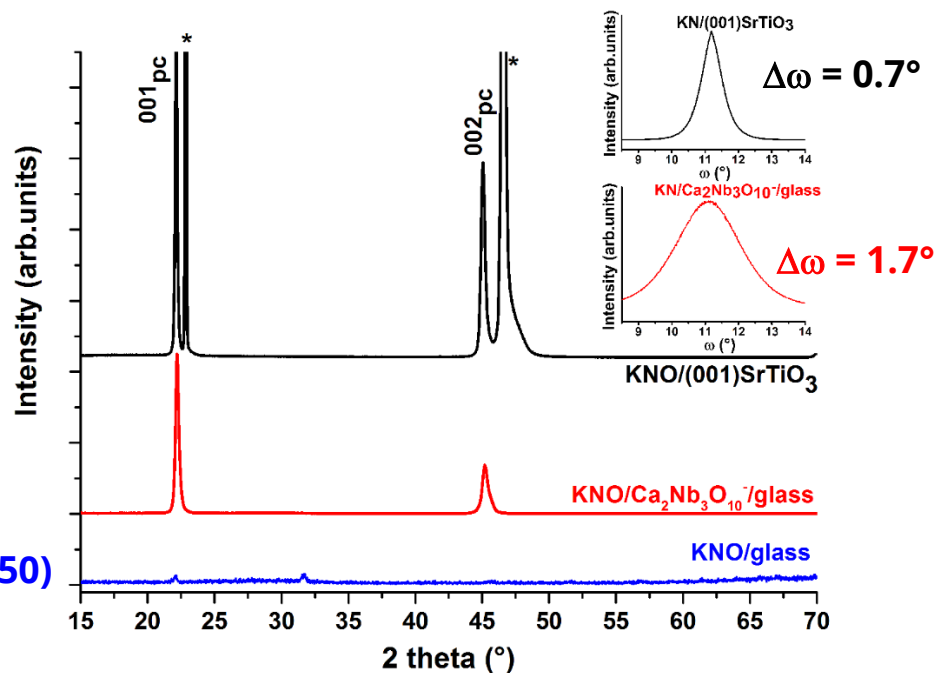
Pseudo-cubic cell:

$a_{pc} = 3.971 \text{ \AA}, b_{pc} = 4.027 \text{ \AA}, c_{pc} = 4.045 \text{ \AA}$

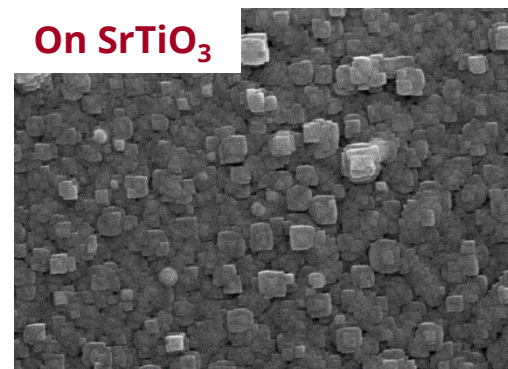
L. Katz and H.D. Megaw. *Acta Cryst.* **22** (1967) 639

S. Kawamura et al. *Jpn J. Appl. Phys.* **52** (2013) 09KF04

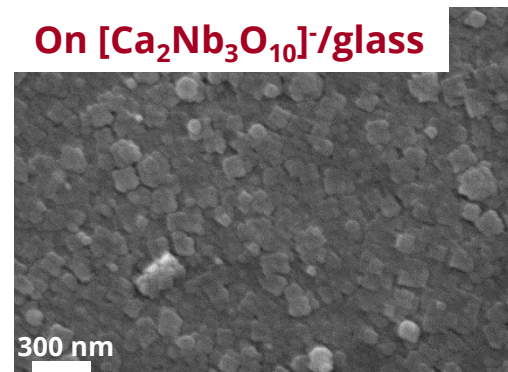
Pulsed Laser Deposition: on SrTiO_3 , on glass, on $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]^-/\text{glass}$



On SrTiO_3



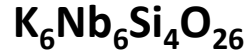
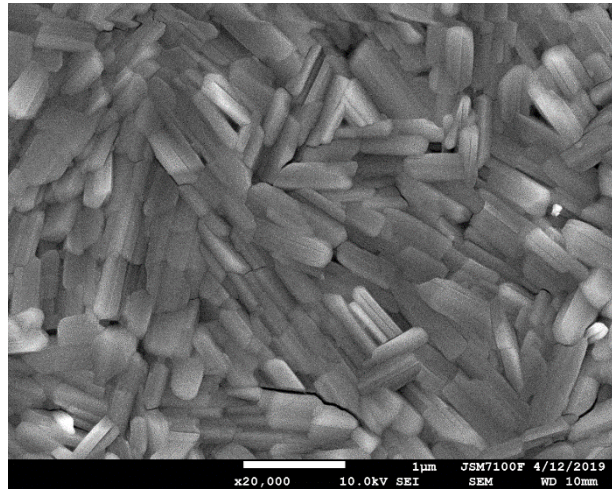
On $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]^-/\text{glass}$



F. Baudouin, V. Demange, S. Ollivier, L. Rault, A.S. Brito, A.S. Maia, F. Gouttefangeas, V. Bouquet, S. Députier, B. Bérini, A. Fouchet, M. Guilloux-Viry. *Thin Solid Films* **693** (2020) 137682

Growth of complex oxides: KNbO_3 on $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]/\text{Si}$

KNbO_3/Si



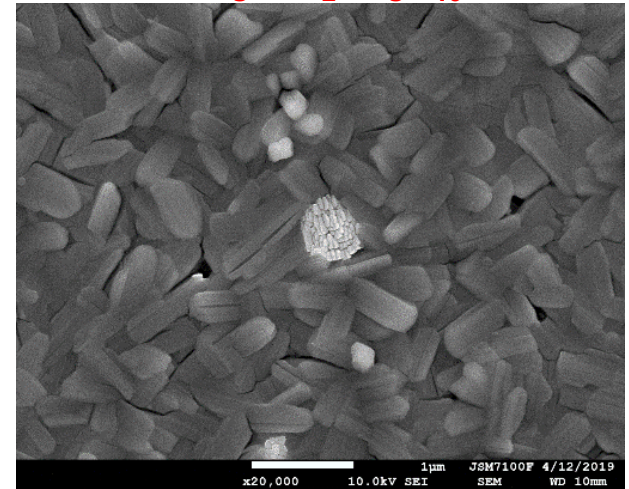
P-62*m*

a = 9.032 Å

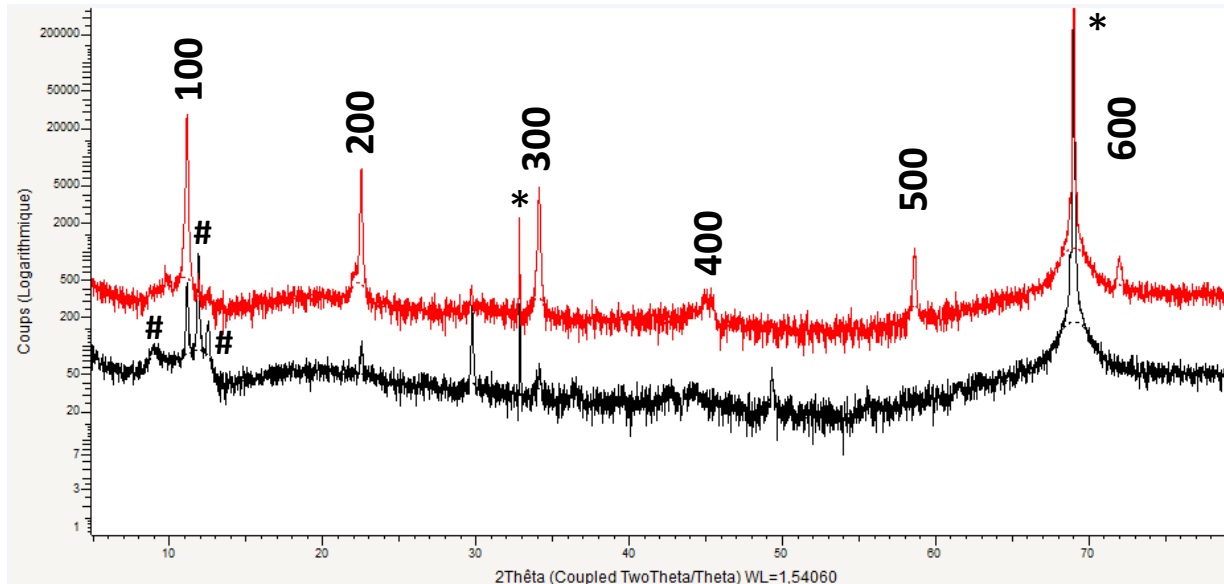
c = 8.041 Å

J. Choisnet *et al.*
Mater. Res. Bull. **11** (1976) 887

$\text{KNbO}_3/[\text{Ca}_2\text{Nb}_3\text{O}_{10}]/\text{Si}$



Thickness
~ 150 nm



on $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]/\text{Si}$

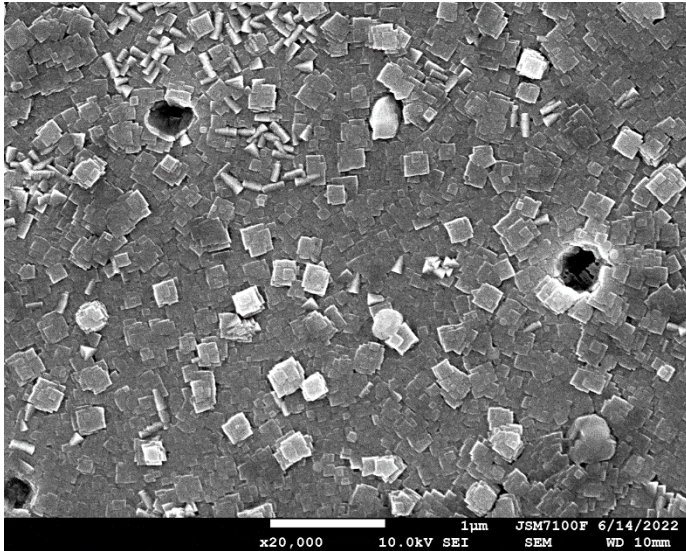
on Si

* : Si

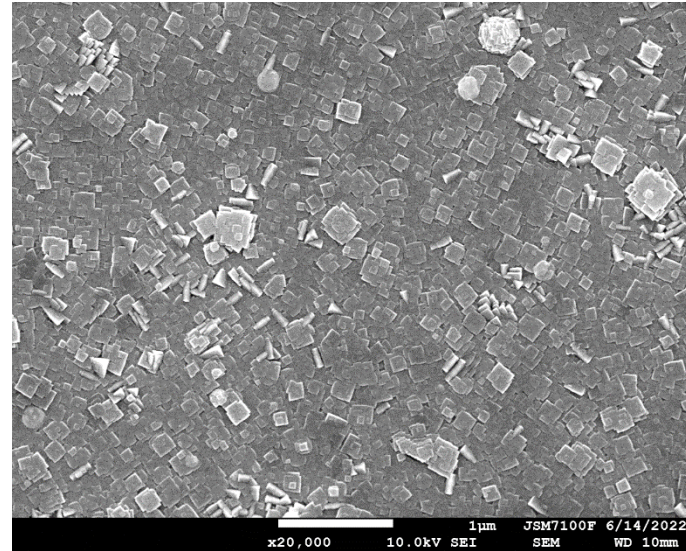
: Unknown phase

Growth of complex oxides: KNbO_3 on $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]/\text{Si}$

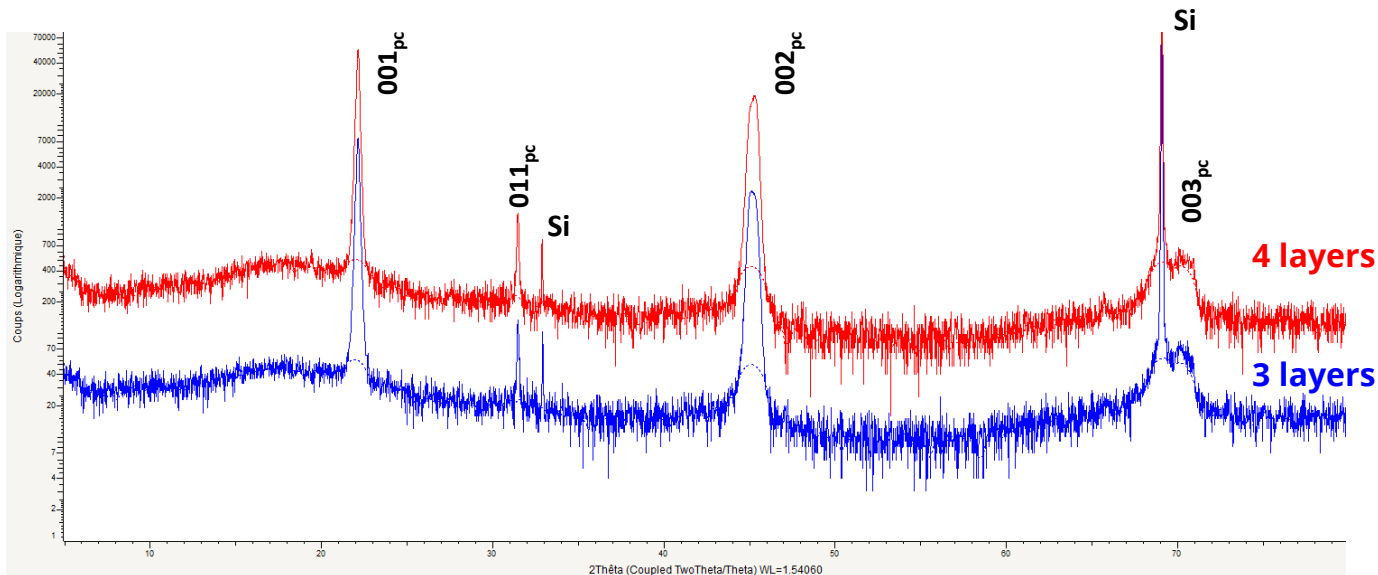
$\text{KNbO}_3/3$ layers $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]/\text{Si}$



$\text{KNbO}_3/4$ layers $[\text{Ca}_2\text{Nb}_3\text{O}_{10}]/\text{Si}$



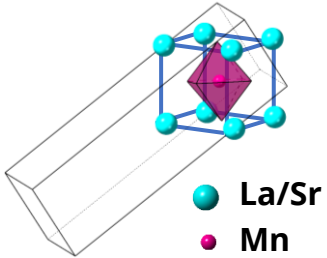
Thickness
~ 150 nm



Magnetic $\text{La}_{0.67}\text{Sr}_{0.33}\text{MnO}_3$ films on glass (PLD)



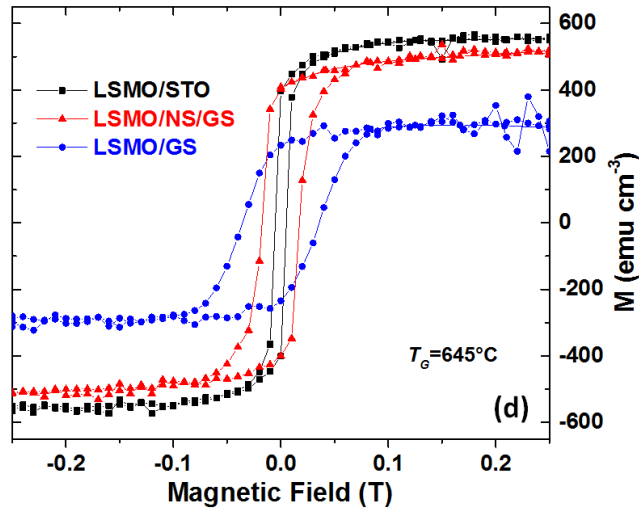
A. Boileau
A. Fouchet



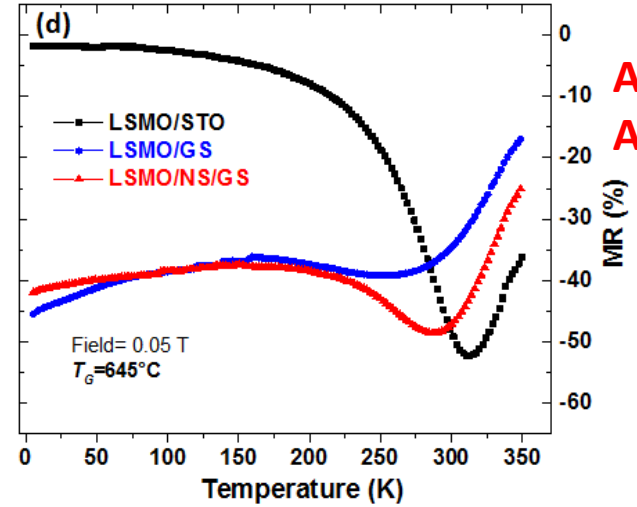
$R\bar{3}c$
 $a = 5.507 \text{ \AA}; c = 13.367 \text{ \AA}$

Pseudo-cubic cell:
 $a_{pc} = 3.882 \text{ \AA}; \alpha = 90.35^\circ$

Magnetization vs field



Magnetoresistance vs T

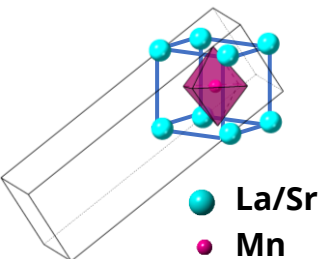


A. Boileau, M. Dallochio, F. Baudouin, A. David, U. Lüders, B. Mercey, A. Pautrat, V. Demange, M. Guilloux-Viry, W. Prellier, A. Fouchet. *ACS Appl. Mater. Int.* **11** (2019) 37302

Magnetic $\text{La}_{0.67}\text{Sr}_{0.33}\text{MnO}_3$ films on glass (PLD)



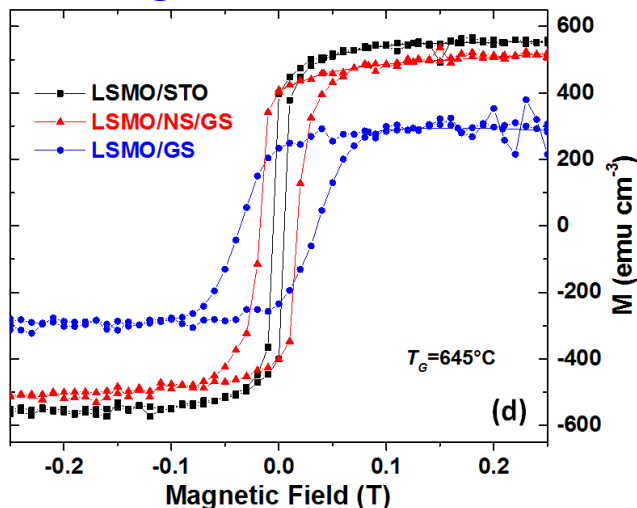
A. Boileau
A. Fouchet



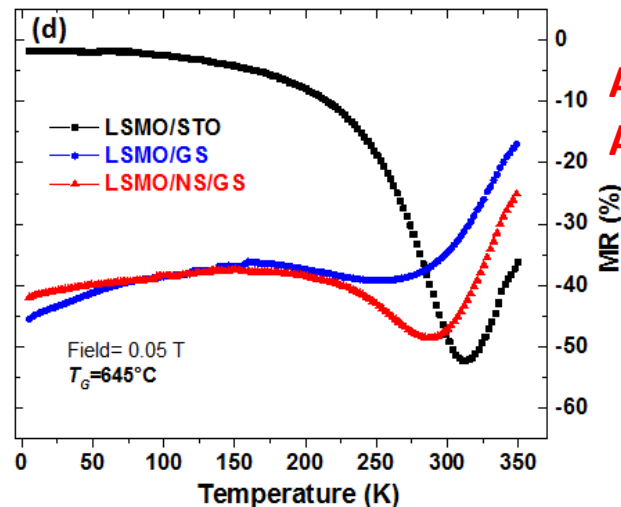
$R\bar{3}c$
 $a = 5.507 \text{ \AA}; c = 13.367 \text{ \AA}$

Pseudo-cubic cell:
 $a_{pc} = 3.882 \text{ \AA}; \alpha = 90.35^\circ$

Magnetization vs field



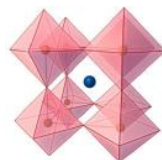
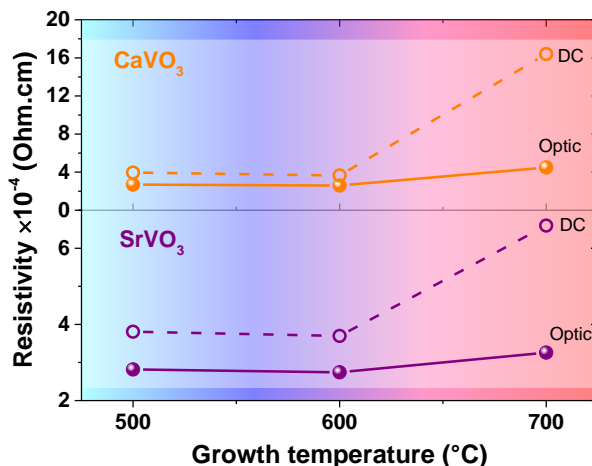
Magnetoresistance vs T



A. Boileau, M. Dallochio, F. Baudouin, A. David, U. Lüders, B. Mercey, A. Pautrat, V. Demange, M. Guilloux-Viry, W. Prellier, A. Fouchet. *ACS Appl. Mater. Int.* **11** (2019) 37302

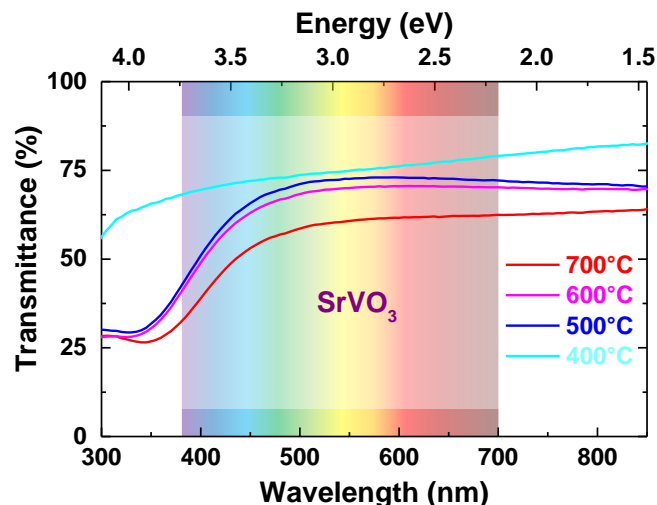
Transparent conducting SrVO_3 and CaVO_3 films on glass (PLD)

Resistivity



$Pm\bar{3}m$
 $a = 3.84 \text{ \AA}$

Transmittance



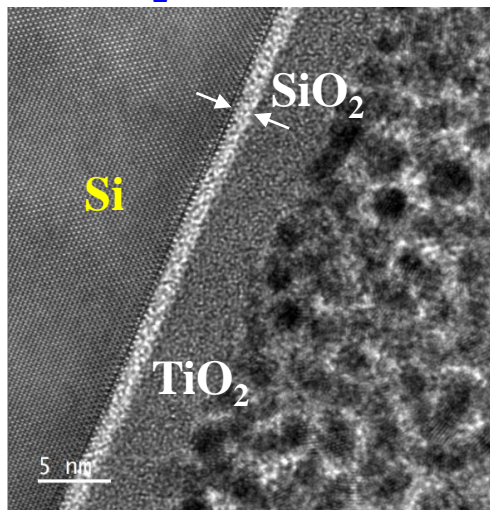
A. Boileau
A. Fouchet

Arnaud
Fouchet's
talk

A. Boileau, S. Hurand, F. Baudouin, U. Lüders, M. Dallochio, B. Béryni, A. Cheikh, A. David, F. Paumier, T. Girardeau, P. Marie, C. Labbé, J. Cardin, D. Aureau, M. Frégnaux, M. Guilloux-Viry, W. Prellier, Y. Dumont, V. Demange, A. Fouchet. *Adv. Func. Mater.* **32** (2022) 2108047

TiO₂ thin films grown by atomic layer deposition (ALD)

5 nm TiO₂ on Si: amorphous



ALD



A. Grishin

B. Bérini

HR(S)TEM



M. Vallet

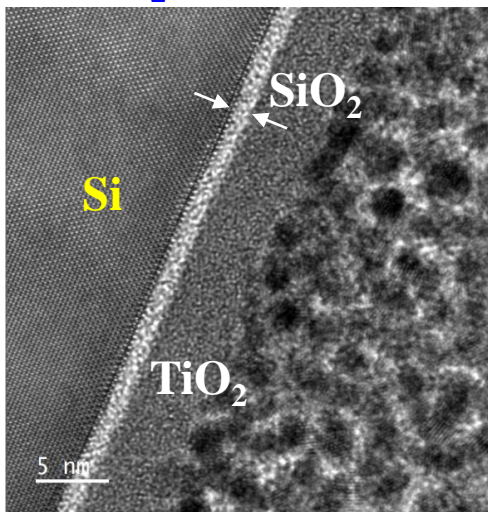
TEM



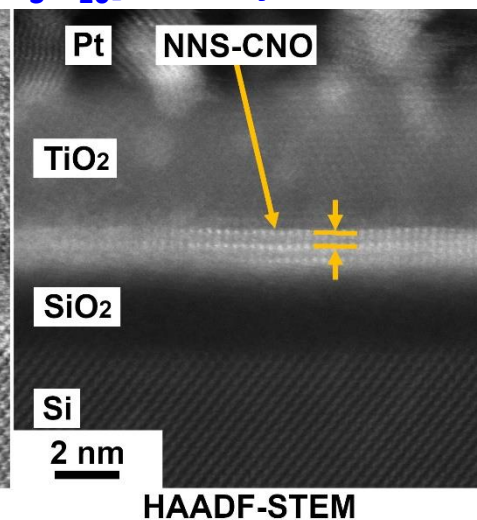
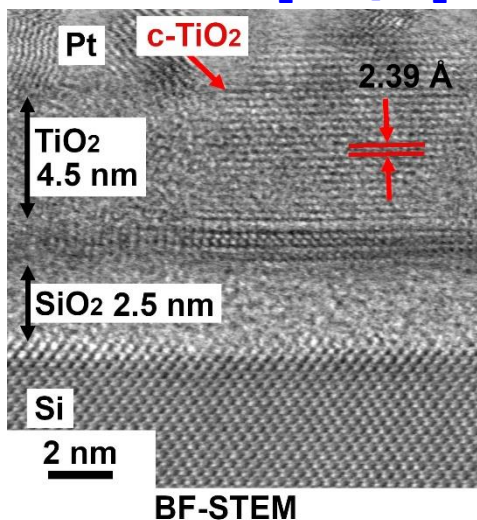
A. Grishin, B. Bérini, M. Vallet, S. Hurand, F. Maudet, C. Sartel, M. Frégnaux, S. Nowak, G. Amiri, S. Hassani, D. Aureau, V. Sallet, V. Demange, Y. Dumont.
Appl. Surf. Science. 641 (2023) 158446

TiO₂ thin films grown by atomic layer deposition (ALD)

5 nm TiO₂ on Si: amorphous



5 nm TiO₂ on [Ca₂Nb₃O₁₀]/Si: crystalline film



ALD



A. Grishin
B. Bérini

HR(S)TEM



M. Vallet

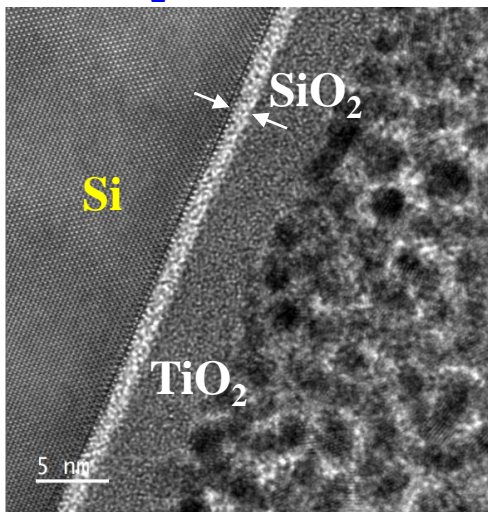
TEM



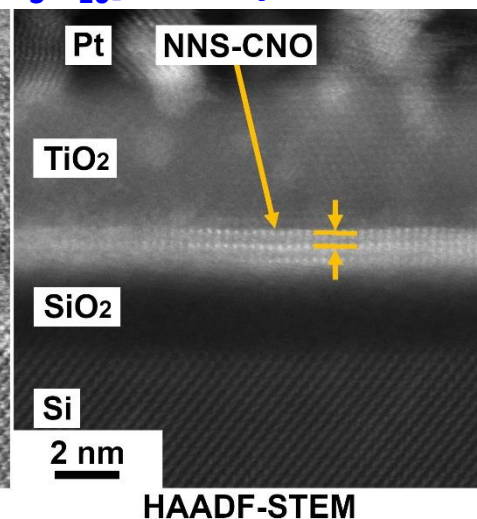
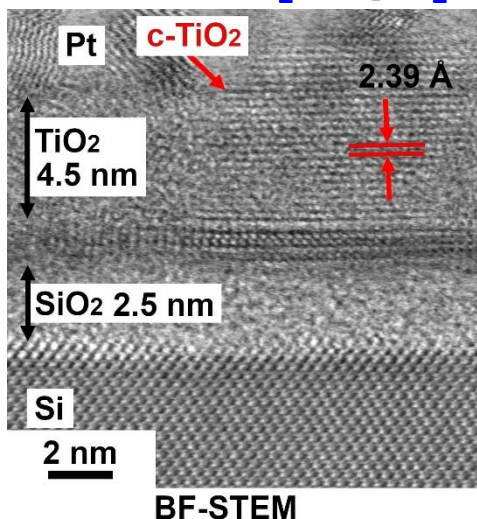
A. Grishin, B. Bérini, M. Vallet, S. Hurand, F. Maudet, C. Sartel, M. Frégnaux, S. Nowak, G. Amiri, S. Hassani, D. Aureau, V. Sallet, V. Demange, Y. Dumont.
Appl. Surf. Science. 641 (2023) 158446

TiO₂ thin films grown by atomic layer deposition (ALD)

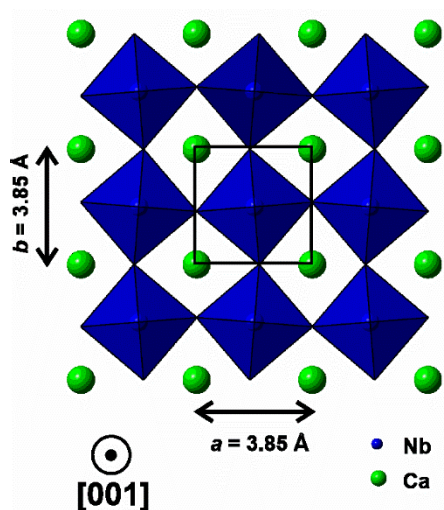
5 nm TiO₂ on Si: amorphous



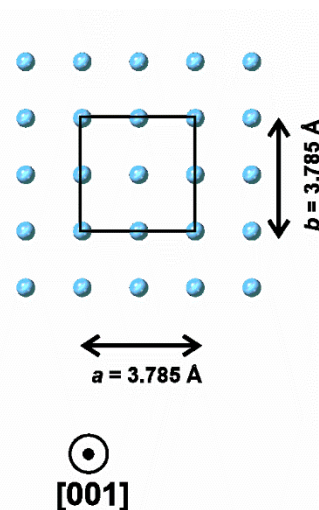
5 nm TiO₂ on [Ca₂Nb₃O₁₀]⁻/Si: crystalline film



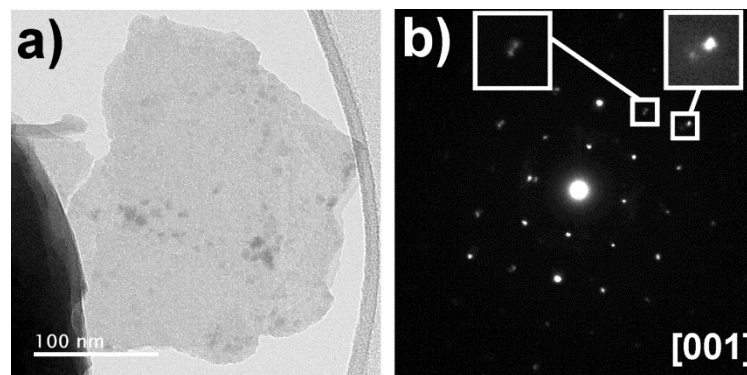
[Ca₂Nb₃O₁₀]⁻



TiO₂



In-plane view TEM



ALD



A. Grishin
B. Bérini

HR(S)TEM



M. Vallet

TEM



A. Grishin, B. Bérini, M. Vallet, S. Hurand, F. Maudet, C. Sartel, M. Frégnaux, S. Nowak, G. Amiri, S. Hassani, D. Aureau, V. Sallet, V. Demange, Y. Dumont. Appl. Surf. Science. 641 (2023) 158446

Crystal size of the parent phase: $\text{KCa}_2\text{Nb}_3\text{O}_{10}$

Molten salts:

Excess of K_2CO_3

Growth temperature

Cooling rate

Salts: KCl , K_2SO_4 , K_2MoO_4

Ratio salt/precursors

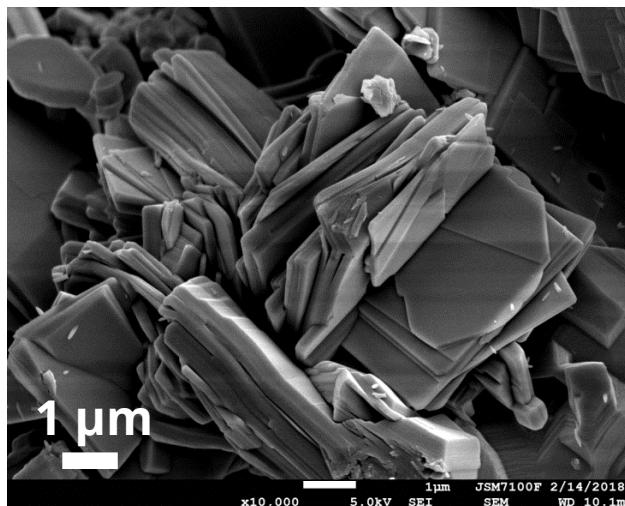


Pure phase

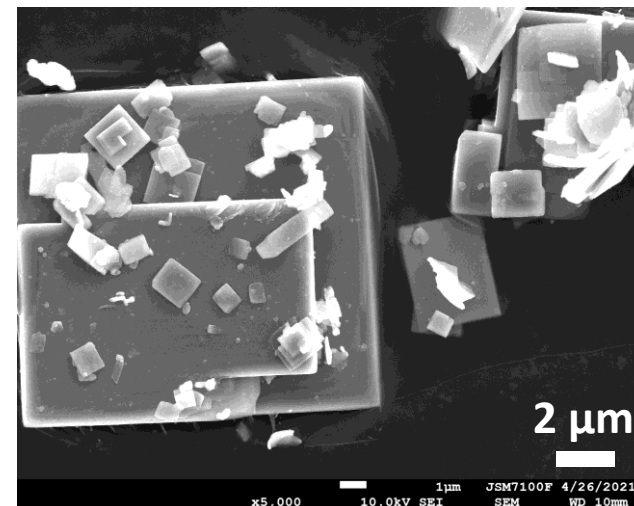
Crystals size

Size distribution

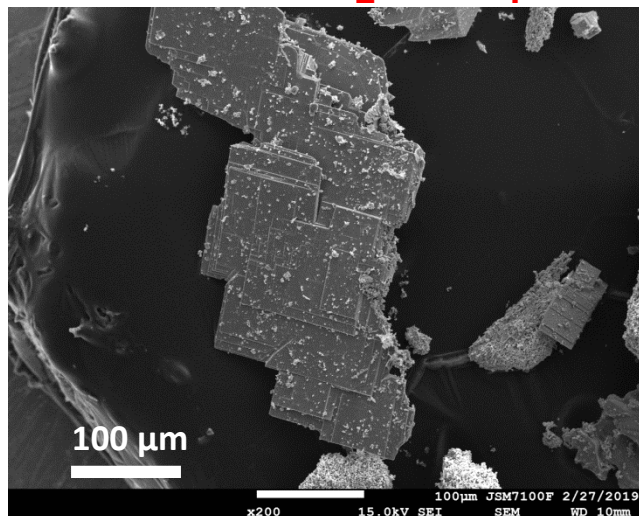
Solid state reaction



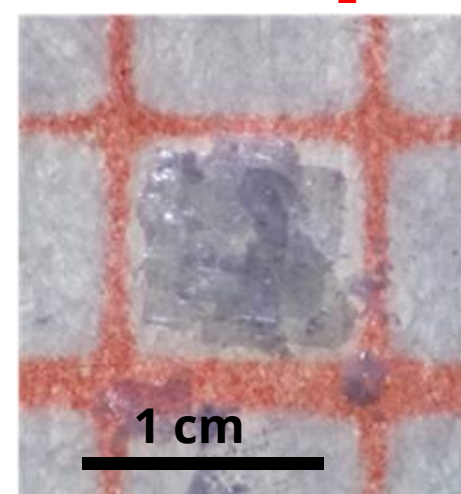
Molten salt: K_2SO_4



Molten salt: K_2MoO_4 (1)



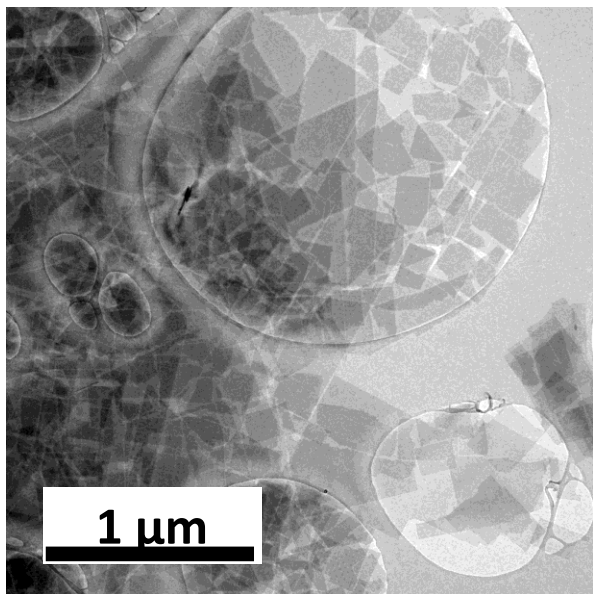
Molten salt 2: K_2MoO_4 (2)



Effect of growth methods of the parent phase on nanosheets size

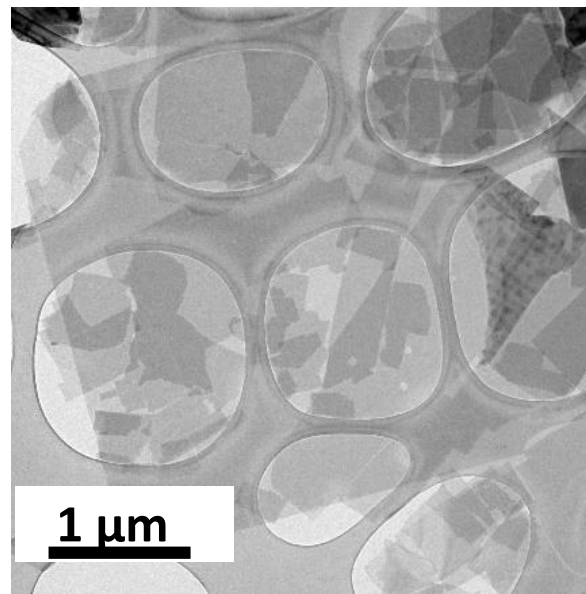
Solid state reaction

~ 0.1 – 0.2 μm



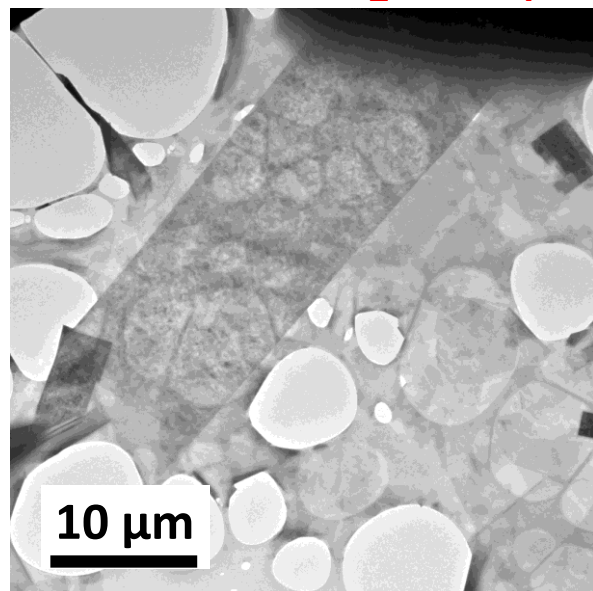
Molten salt: K_2SO_4

~ 2 – 5 μm



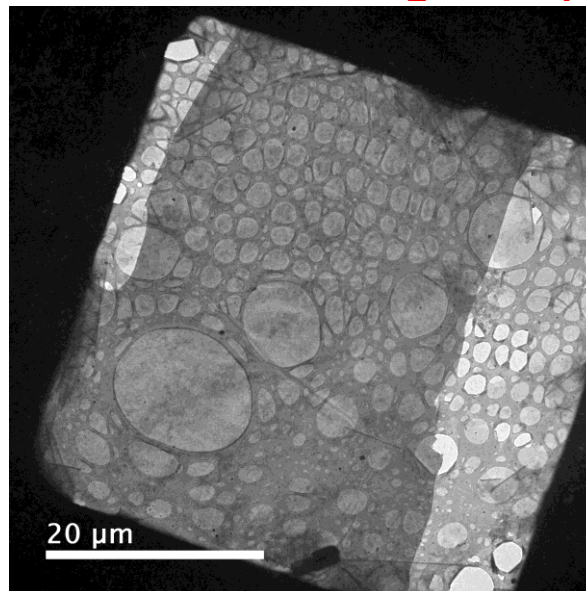
Molten salt: K_2MoO_4 (1)

~ 10 – 50 μm



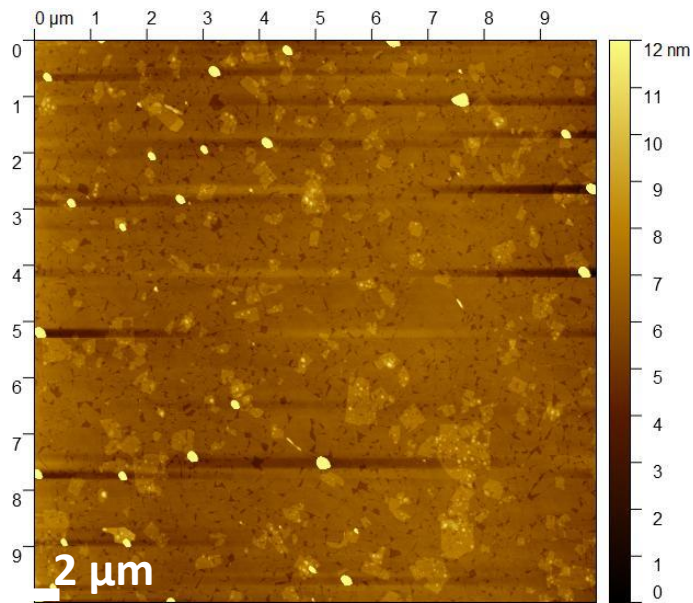
Molten salt 2: K_2MoO_4 (2)

> 50 μm



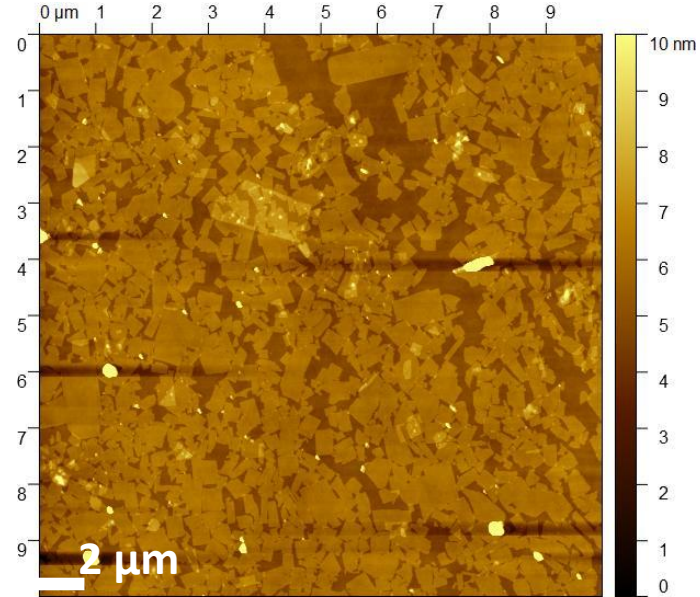
After transfer on substrates

Solid state reaction



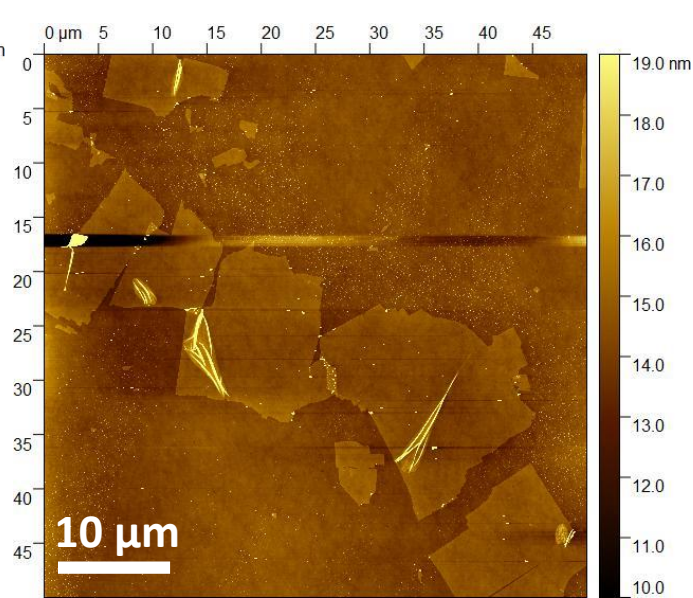
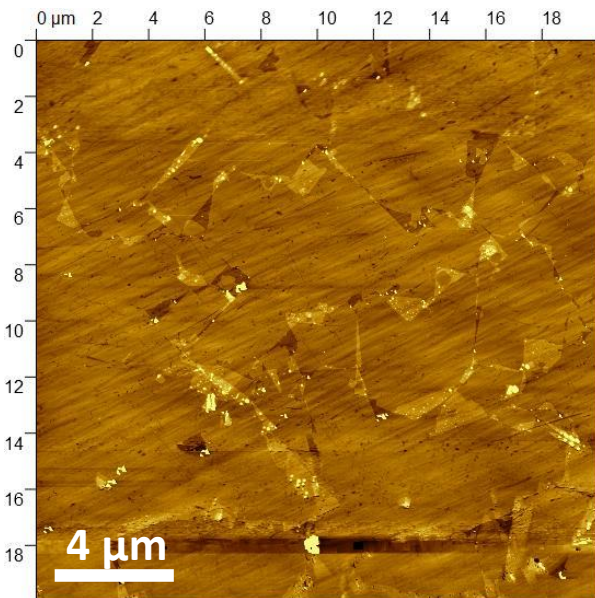
$\sim 0.1 - 0.2 \mu\text{m}$

Molten salt: K_2SO_4



$\sim 0.2 - 0.5 \mu\text{m}$

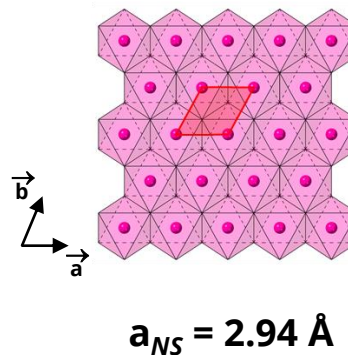
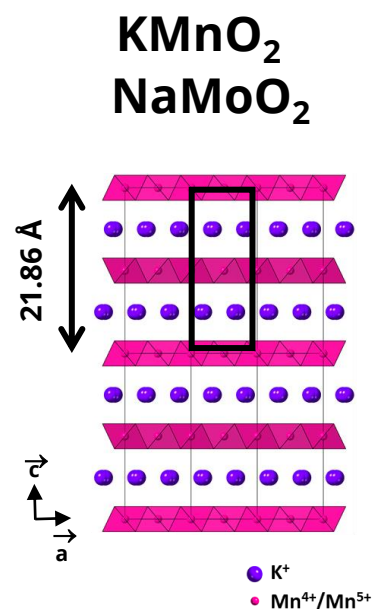
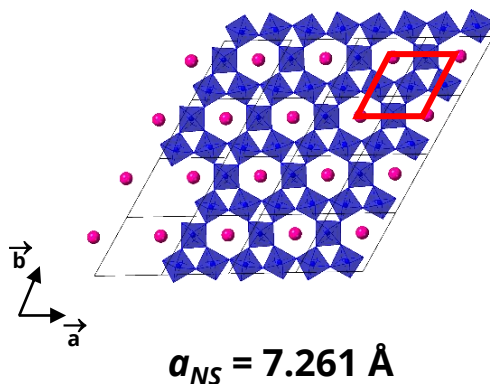
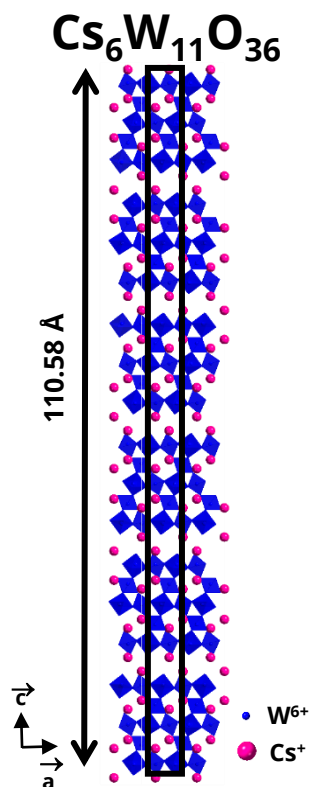
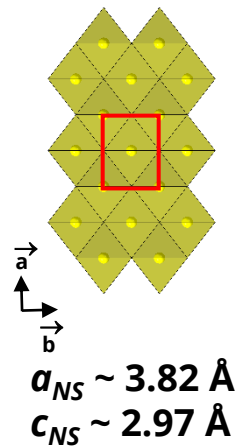
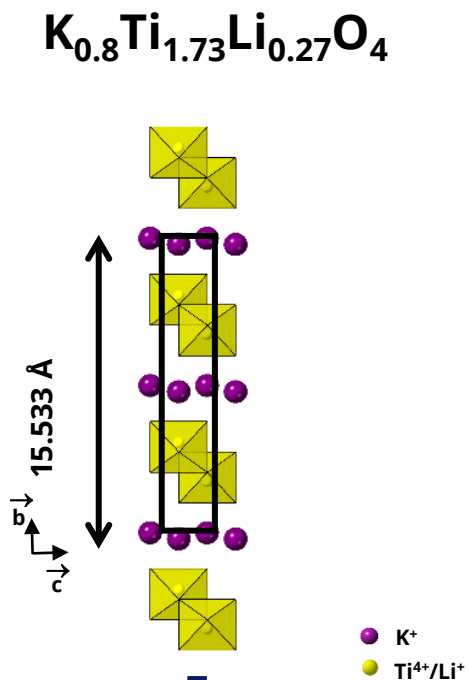
Molten salt: K_2MoO_4 (1) $\sim 5-20 \mu\text{m}$



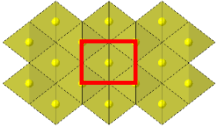
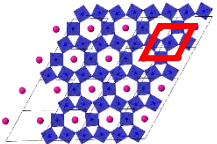
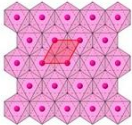
Molten salt: K_2MoO_4 (2)

Drop casting doesn't work

Other nanosheets for oxide growth

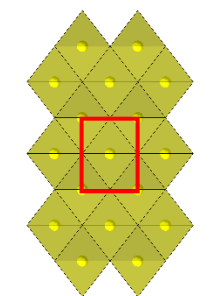


Nanosheets for preferential orientation of oxides on any substrate

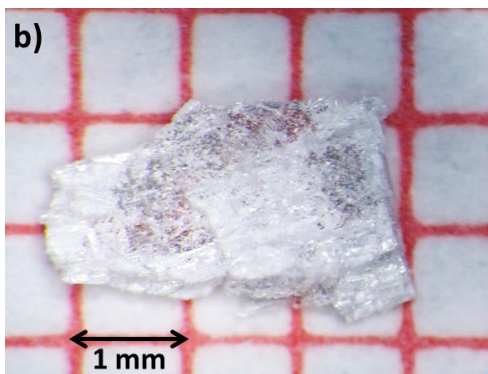
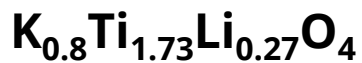
Nanosheets (NS)	2D lattice	Grown films on NS	Substrates
$[\text{Ti}_{0.87}\text{O}_2]^{0.52-}$	Rectangle $a_{NS} \sim 3.82 \text{ \AA}$ $c_{NS} \sim 2.97 \text{ \AA}$ 	(110)SrTiO ₃	Glass
		(110)SrRuO ₃	Si
		(110)Pb(Zr,Ti)O ₃	Si, Si ₃ N ₄
		(011)VO ₂	Si, Pt/TiO ₂ /Si
$[\text{Cs}_4\text{W}_{11}\text{O}_{36}]^{2-}$	Hexagonal $a_{NS} = 7.261 \text{ \AA}$ 	(001)ZnO	Glass, polymer
$[\text{MnO}_2]^{0.45-}$	Hexagonal $a_{NS} = 2.94 \text{ \AA}$ 	(001)ZnO	Glass
$[\text{MoO}_2]^{6-}$	Hexagonal $a_{NS} = 2.90 \text{ \AA}$	(111)SrTiO ₃	Glass
$[\text{NbWO}_6]^-$	Square $a_{NS} = 4.68 \text{ \AA} \times 4.68 \text{ \AA}$	(-402)VO ₂	Si, Si ₃ N ₄

Refs: Sasaki's articles, Ten Elshof articles, ...

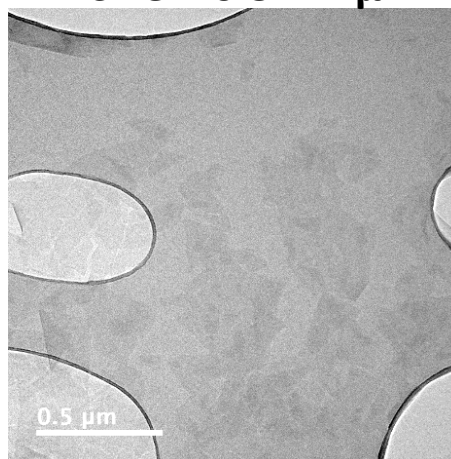
$[\text{Ti}_{0.865}\text{O}_2]^{0.54-}$ nanosheets for (110) perovskite growth



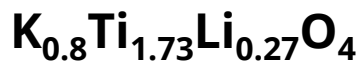
$a_{NS} \sim 3.82 \text{ \AA}$
 $c_{NS} \sim 2.97 \text{ \AA}$



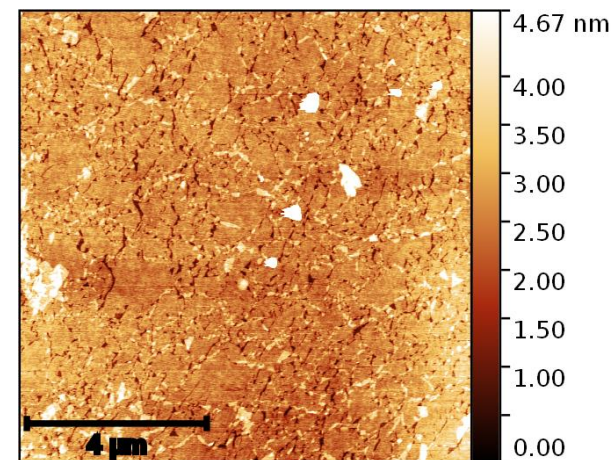
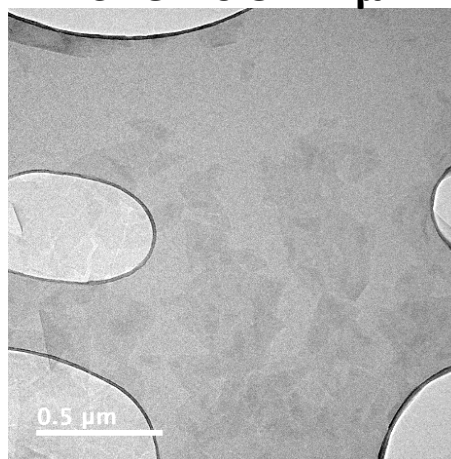
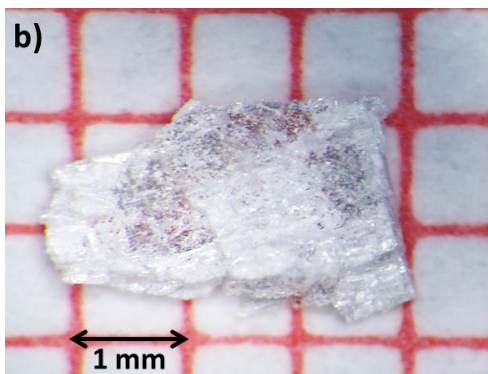
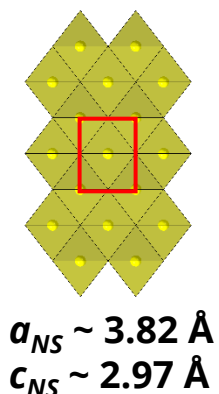
Size $\sim 0.5 - 1 \mu\text{m}$



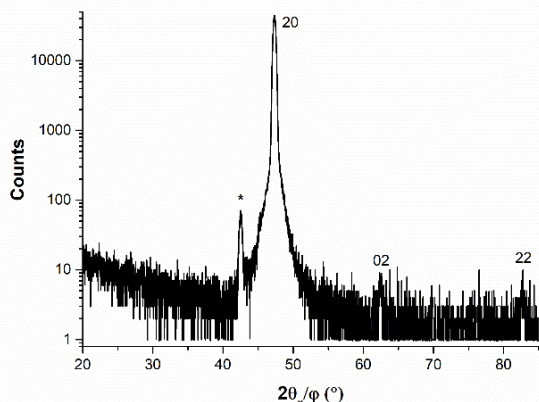
[Ti_{0.865}O₂]^{0.54-} nanosheets for (110) perovskite growth



Size ~ 0.5 – 1 μm



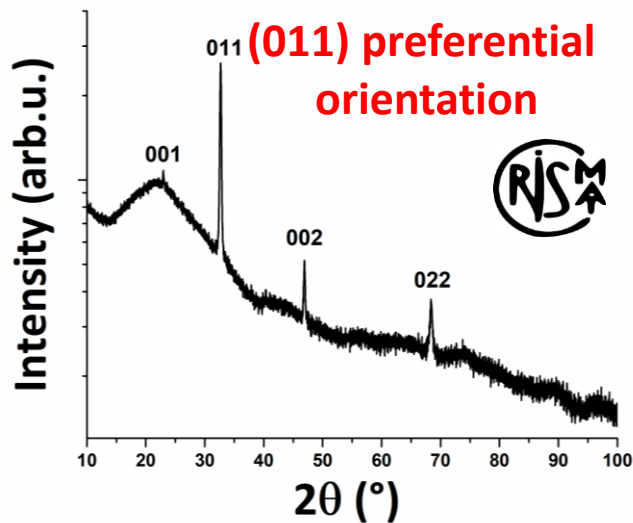
In-plane XRD



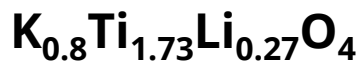
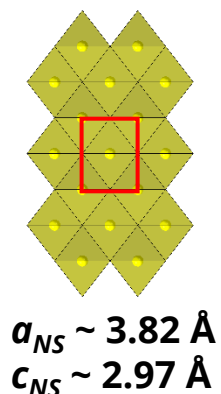
$a = 3.84 \text{ \AA}$
 $c = 2.97 \text{ \AA}$

*: K_β line of the 20 reflection

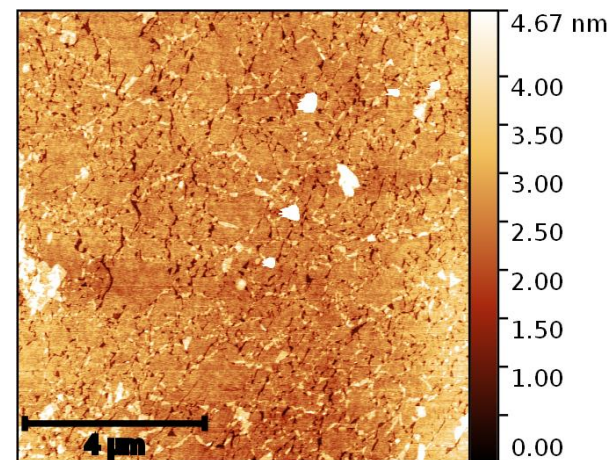
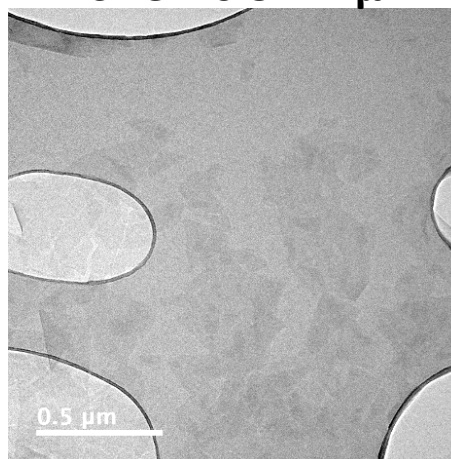
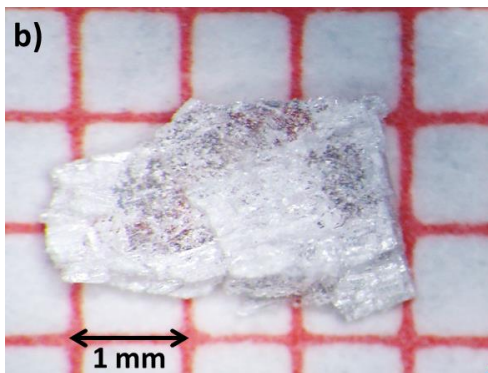
Growth of $La_{0.67}Sr_{0.33}MnO_3$ on [Ti_{0.865}O₂]^{0.54-}/glass



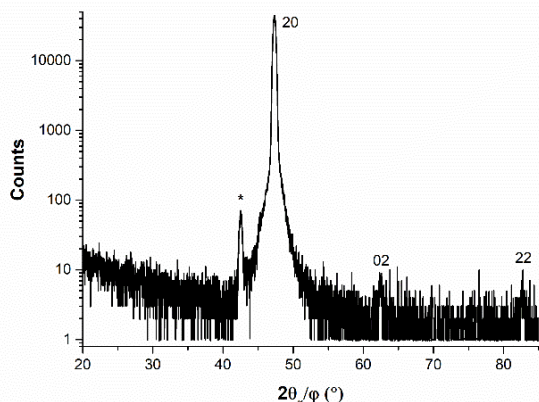
[Ti_{0.865}O₂]^{0.54-} nanosheets for (110) perovskite growth



Size $\sim 0.5 - 1 \mu\text{m}$



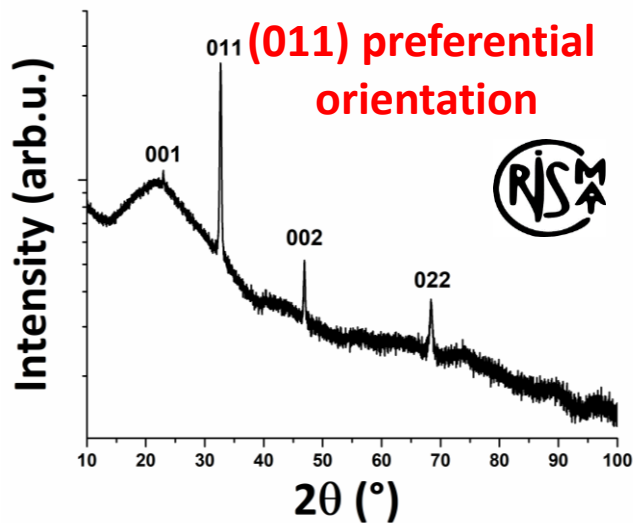
In-plane XRD



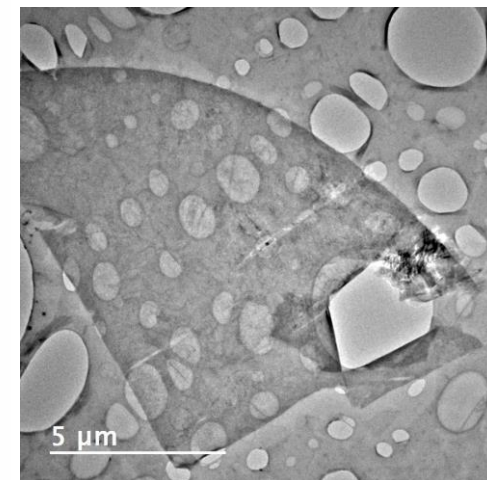
$a = 3.84 \text{ \AA}$
 $c = 2.97 \text{ \AA}$

*: K_{β} line of the 20 reflection

Growth of $La_{0.67}Sr_{0.33}MnO_3$ on [Ti_{0.865}O₂]^{0.54-}/glass

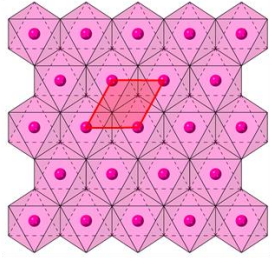


[(Ti,Co,Fe)_{0.865}O₂]^{0.54-}



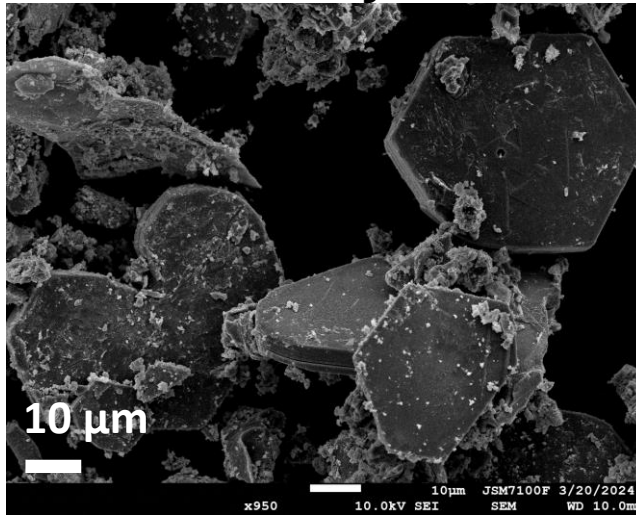
[MnO₂]^{0.45}- nanosheets for (111) perovskite growth

~~NaMoO₂~~

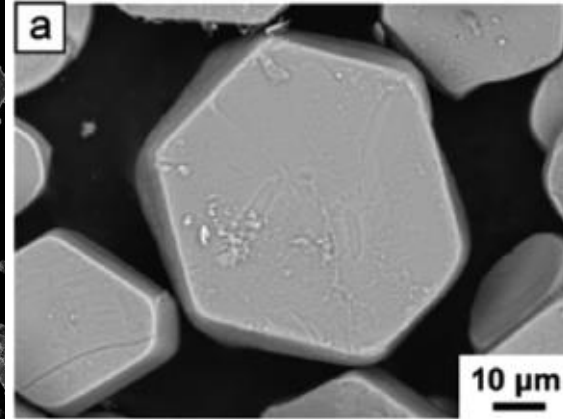


$$a_{NS} = 2.94 \text{ \AA}$$

KMnO₂
(4 days)

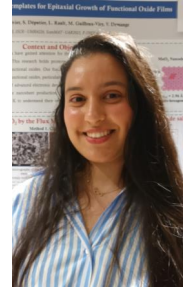


Yano *et al.*
(3 months)



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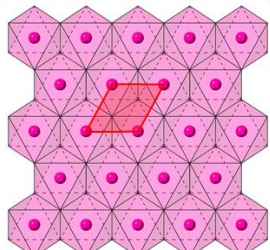
See
Sahar Gaddour's
poster



Master 2

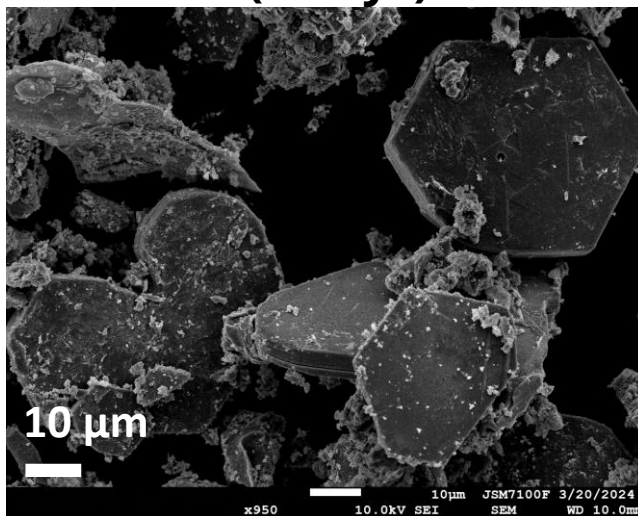
[MnO₂]^{0.45}-nanosheets for (111) perovskite growth

~~NaMoO₂~~

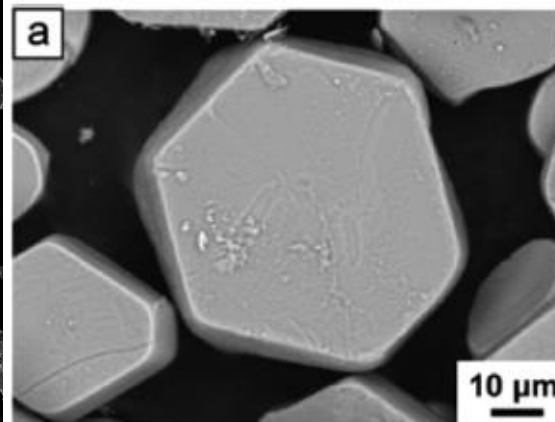


$$a_{NS} = 2.94 \text{ \AA}$$

KMnO₂
(4 days)



Yano *et al.*
(3 months)



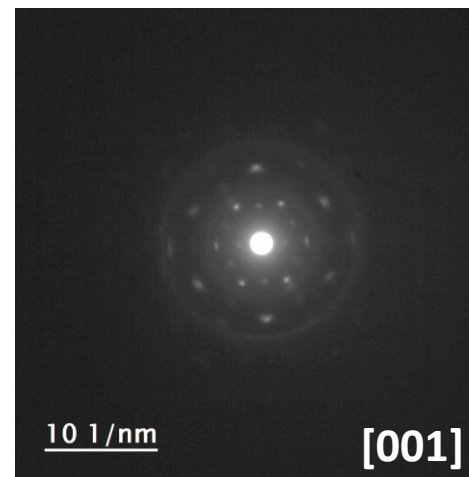
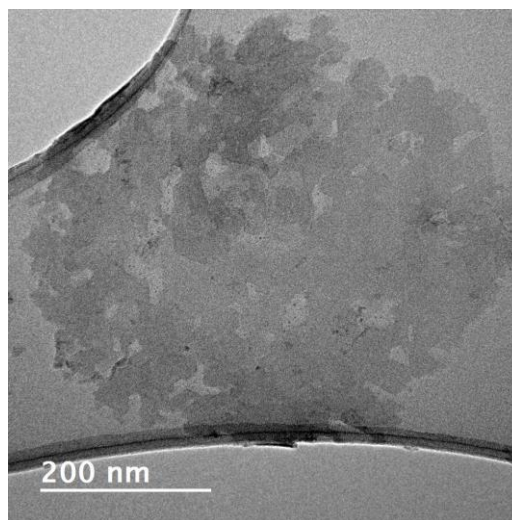
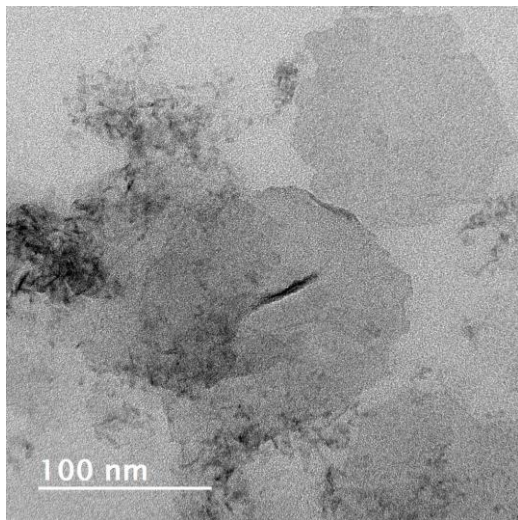
Yano *et al.* Cryst. Growth Des. (2022) 22

See
Sahar Gaddour's
poster



Master 2

First attempt of exfoliation



TEM



L. Rault

Conclusions

- Integration of various oxides (including oxides that react with Si) on Si and glass thanks to nanosheets

- Excellent properties of thin films grown on Si or glass

- Easy process, large surface

- Synthesized nanosheets:



and also : $[\text{K}_{4-x}\text{Nb}_6\text{O}_{17}]^{x-}$, $[\text{Cs}_4\text{W}_{11}\text{O}_{36}]^{2-}$, $[(\text{Ti},\text{Co},\text{Fe})_{0.865}\text{O}_2]^{0.54-}$

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"PolyNash" ANR-17-CE08-0012

"Flexo" ANR ANR-21-CE09-0046

"DisTCOvery" ANR-23-CE08-0008-05

